

# Practice Course in Plasma

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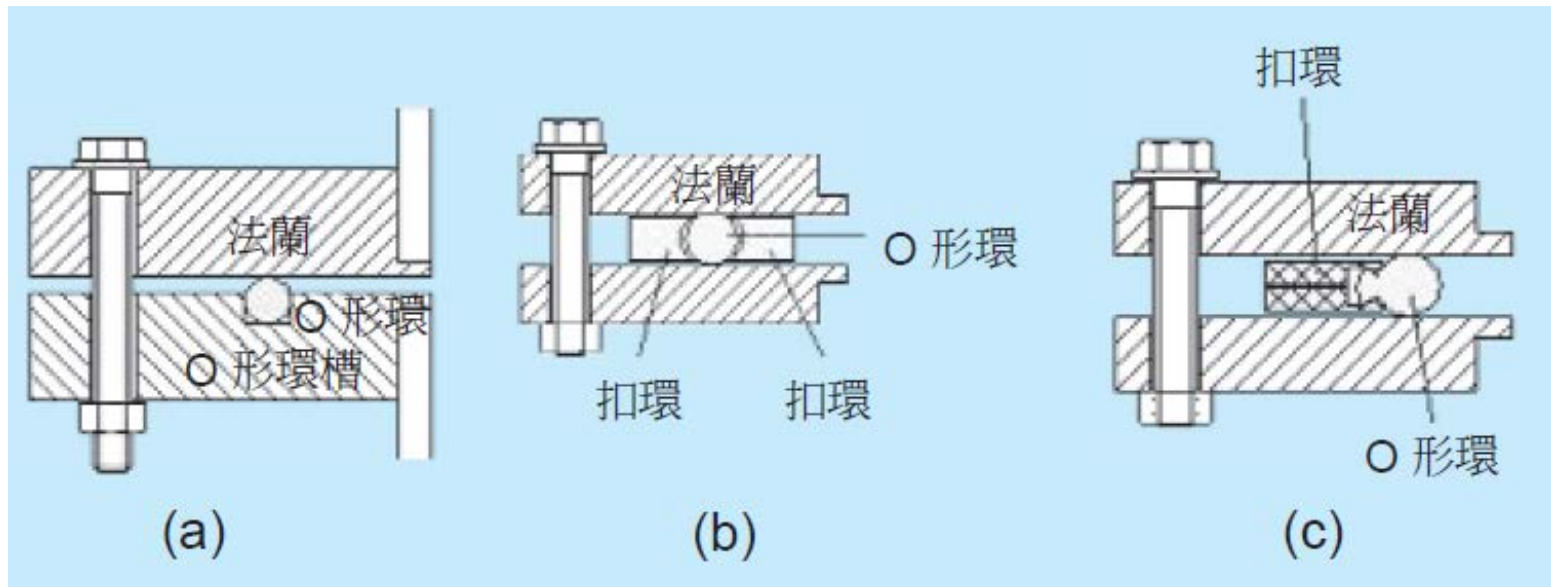
**2021 spring semester**

**Thursday 9:10-12:00**

**Material: <http://capst.ncku.edu.tw/PGS/index.php/teaching/>**

**Lecture 7**

# 可拆卸真空封合 – O-ring



# O-ring groove design



特徵尺寸					
A	$1.15d$	$1.4d$	$1.4d$	$0.9d - 0.95d$	$d$
B	$0.72d$	$0.7d$	$0.7d$	$0.75d - 0.8d$	$1.15d - 1.3d$
R	$0.15d - 0.22d$ 圓角磨光 $R_a < 1.6 \mu\text{m}$	$0.15d - 0.22d$ 圓角磨光 $R_a < 1.6 \mu\text{m}$	$0.15d - 0.22d$ 圓角磨光 $R_a < 1.6 \mu\text{m}$	$0.15d - 0.22d$ 圓角磨光 $R_a < 1.6 \mu\text{m}$	$0.15d - 0.22d$ 圓角磨光 $R_a < 1.6 \mu\text{m}$

# More clamp

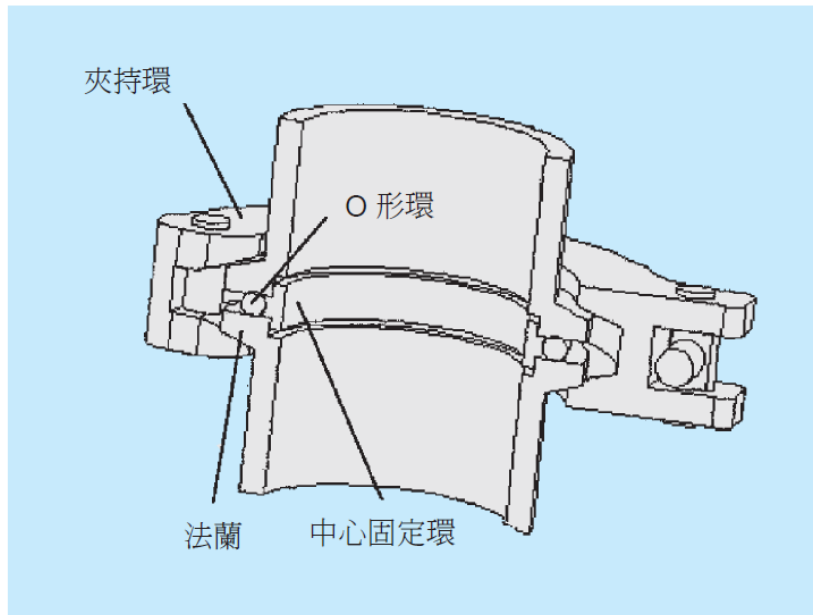


圖 3. KF 法蘭封合結構示意圖。

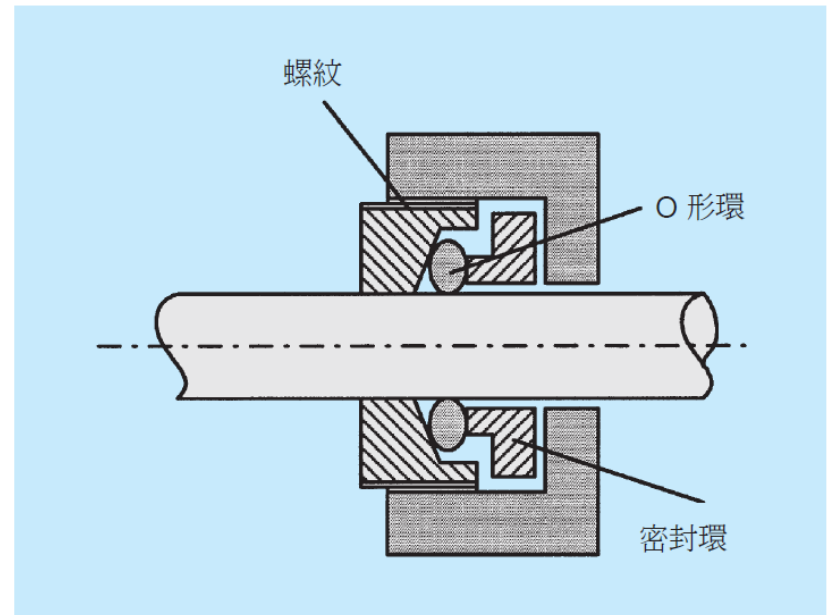
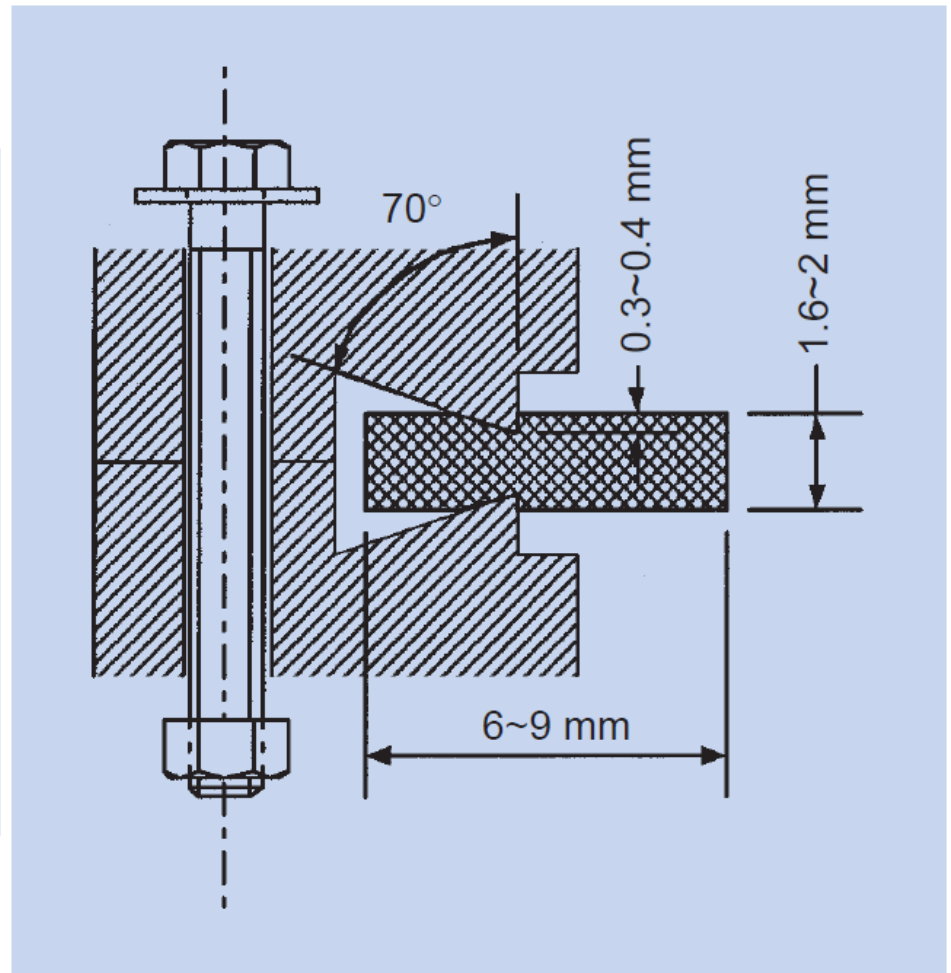
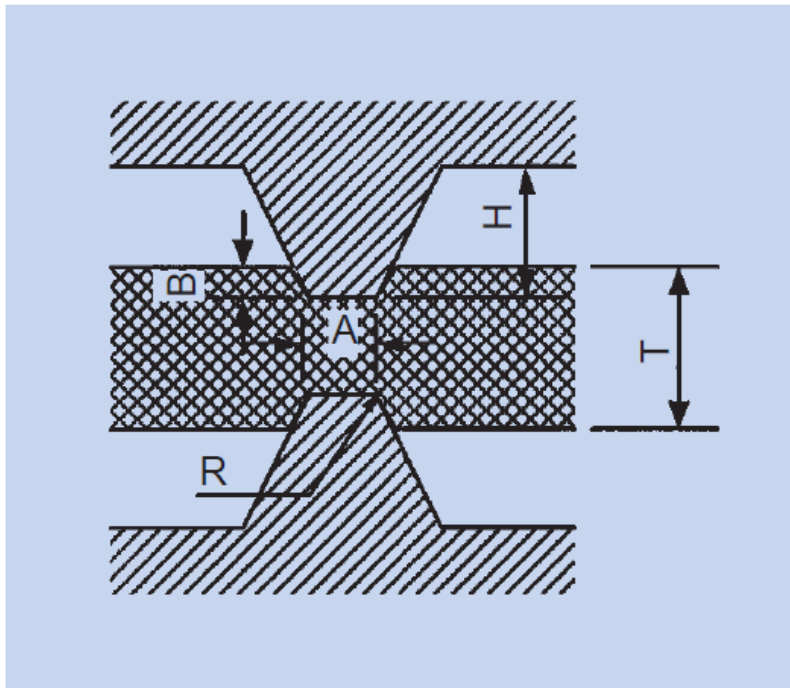


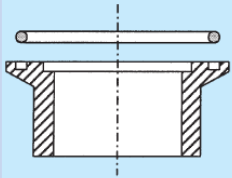
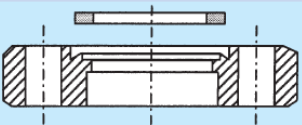
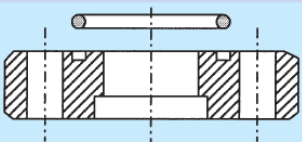
圖 4. 管路之錐形壓縮封合。

# 金屬墊圈刀刃及斜楔法蘭封合

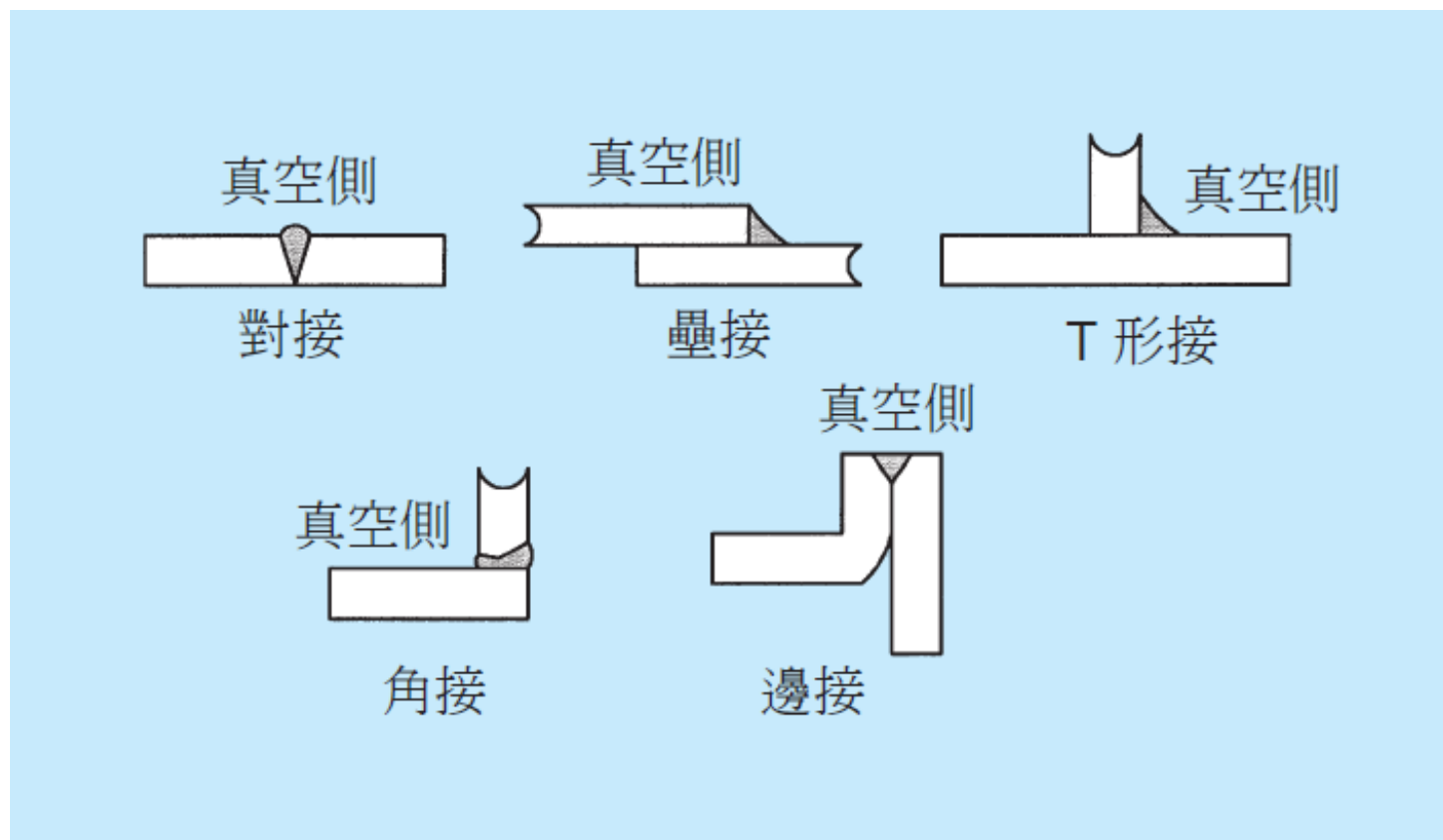


# Comparison of different types of flange



法蘭種類	適用系統	特 性
 <p>ISO 法蘭</p>	<p>中低真空系統及無需烘烤之高真空系統 (壓力大於 <math>10^{-8}</math> Torr 之系統使用) 使用 Viton O 形環烘烤至 <math>200\text{ }^{\circ}\text{C}</math>，操作溫度可達 <math>150\text{ }^{\circ}\text{C}</math>。</p>	<p>高分子封合材料 O 形環，可重覆使用，可以使用固定中心環和平面法蘭或在法蘭上以環槽固定 O 形環，組裝拆卸快速、成本較為經濟。 組裝時可使用真空油脂輕輕塗覆 O 形環，可以提高封合性能。 小管徑使用夾緊環 (hing clamp)，手動鎖緊即可，較為方便，大管徑則使用緊固扣環 (claw clamp)。</p>
 <p>CF 法蘭 (conflat 法蘭)</p>	<p>超高真空系統封合 (壓力小於 <math>10^{-8}</math> Torr 之系統使用)。 可使用金屬墊圈及 Viton O 形環，若使用 Viton O 形環可烘烤至 <math>200\text{ }^{\circ}\text{C}</math>，操作溫度可達 <math>150\text{ }^{\circ}\text{C}</math>。</p>	<p>金屬墊圈封合材料以及 Viton O 形環，封合滲漏很微小。法蘭刀口及封合面的尺寸精度及表面粗糙度要求高。需依要求進行清潔與螺絲組裝程序。</p>
 <p>ASA-ANSI 法蘭</p>	<p>中低真空系統及無需烘烤之高真空系統 (壓力大於 <math>10^{-8}</math> Torr 之系統使用) 使用 Viton O 形環可烘烤至 <math>200\text{ }^{\circ}\text{C}</math>，操作溫度可達 <math>150\text{ }^{\circ}\text{C}</math>。</p>	<p>高分子封合材料 O 形環，封合效果較 ISO 法蘭佳。可熔接或硬焊於腔體或元件需依要求進行清潔與螺絲組裝程序。</p>

# 永久封合



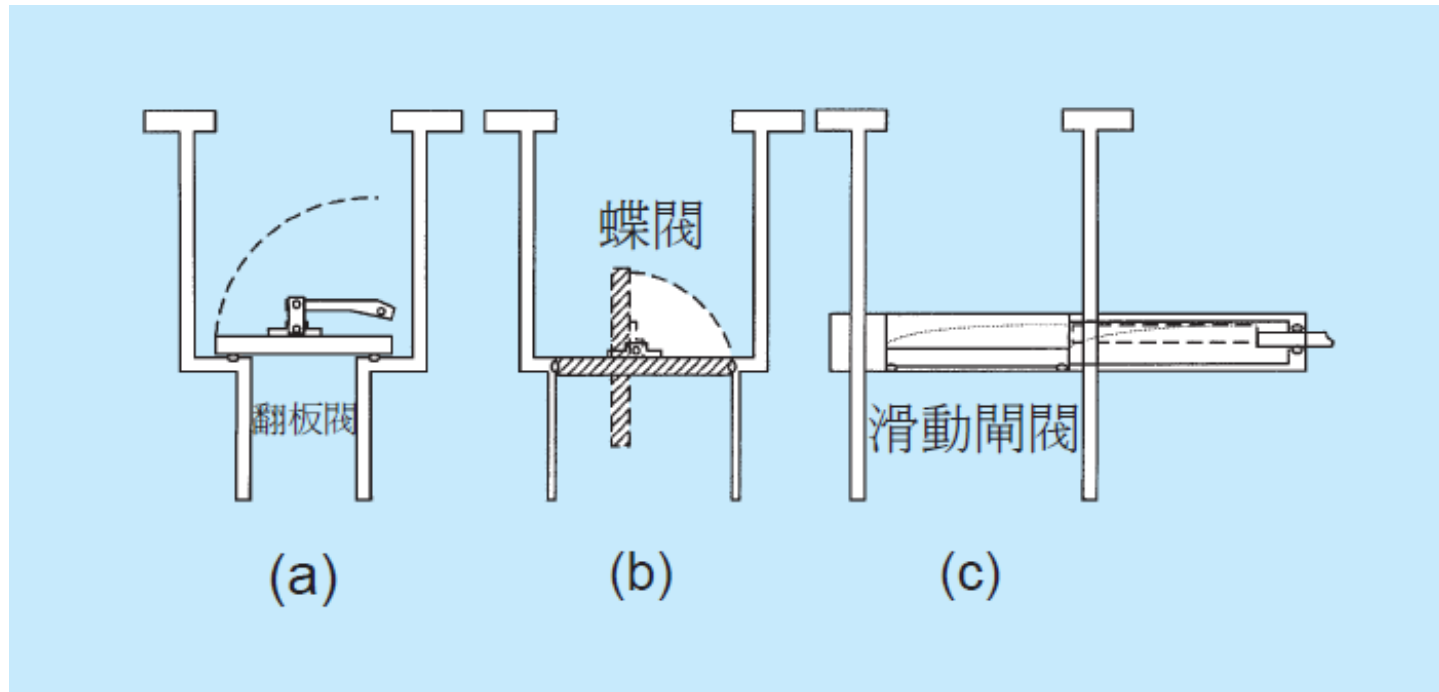
# 真空閥門分類



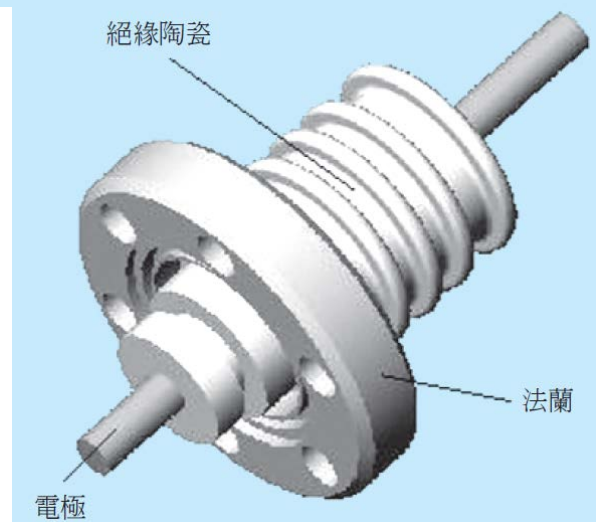
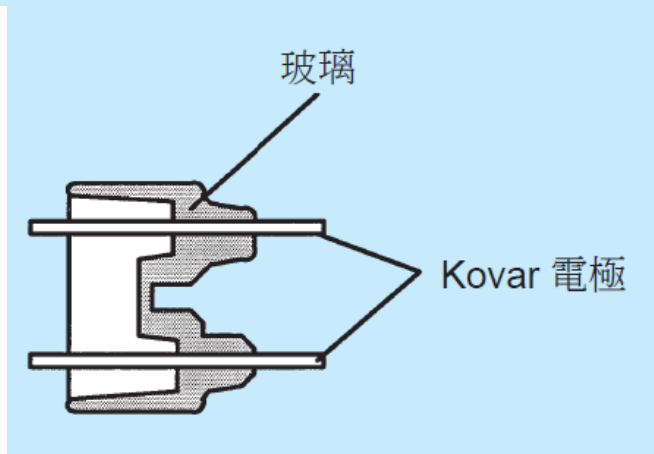
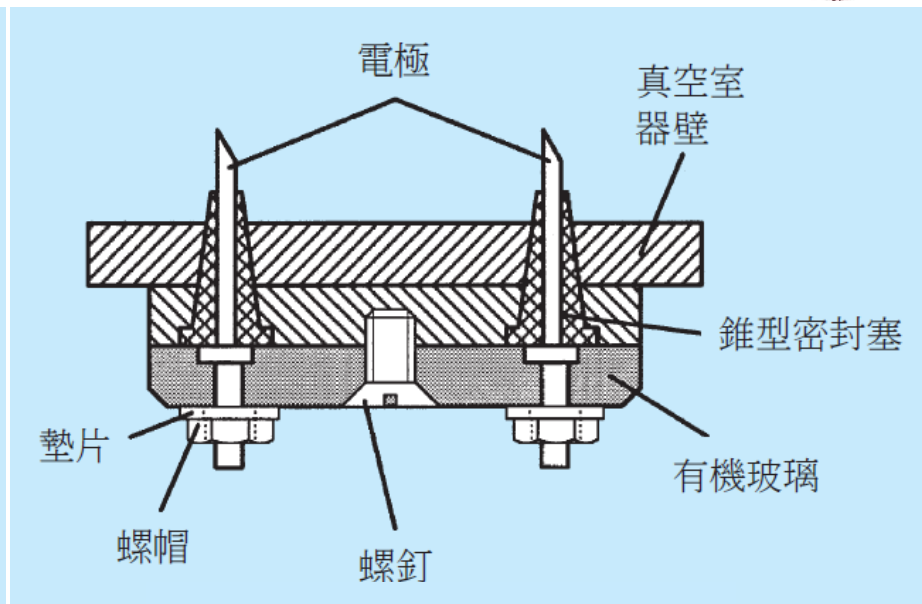
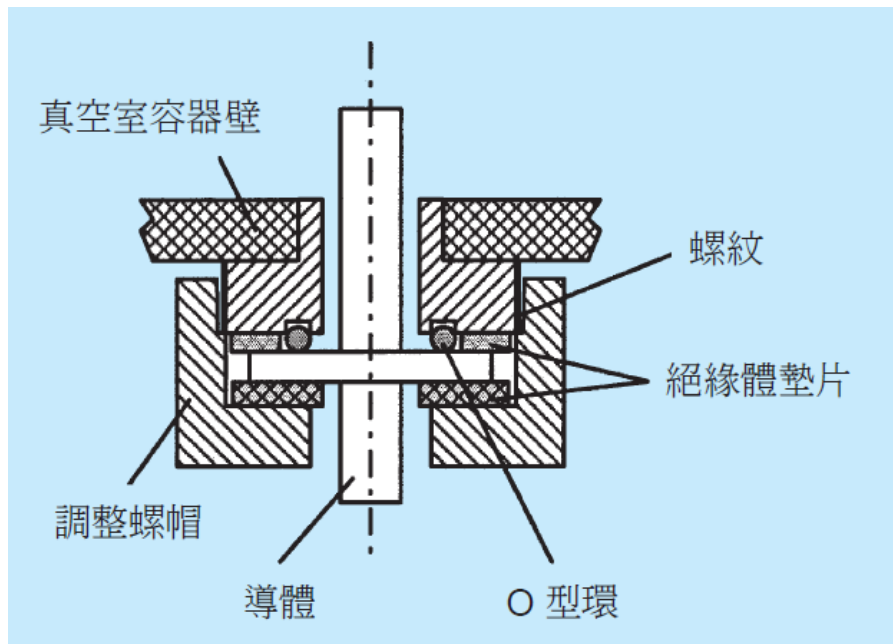
分類依據	閥門名稱
工作壓力	中低真空閥、高真空閥、超高真空閥
用途	截止閥、隔絕閥、放氣閥、節流閥、換向閥、封閉送料閥
驅動方式	手動閥、電動閥、手電兩用閥、電磁閥、氣動閥、液壓式真空閥
材料	玻璃龍頭閥、金屬真空閥
結構特點	擋板閥、翻板閥、蝶閥、連桿閥、隔板閥、閘閥、雙通閥、三通閥、四通閥、直通閥、角閥



# 閘閥結構

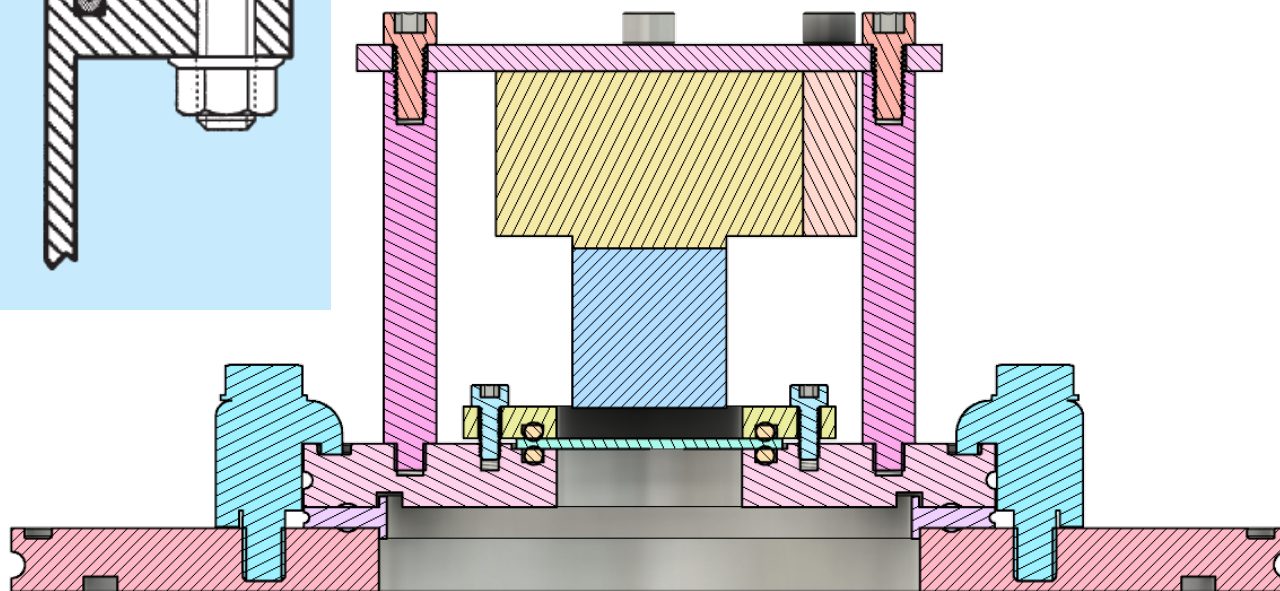
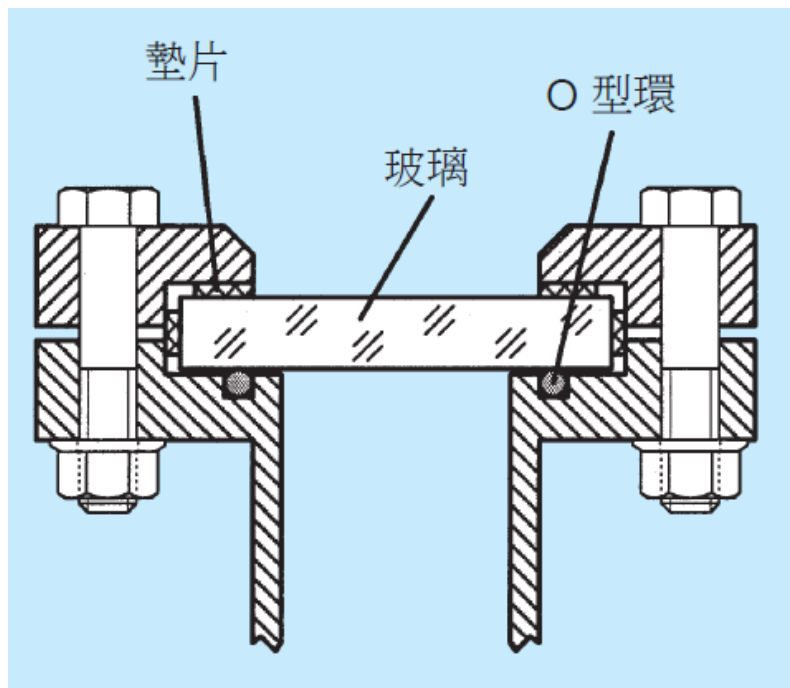


# 電引入

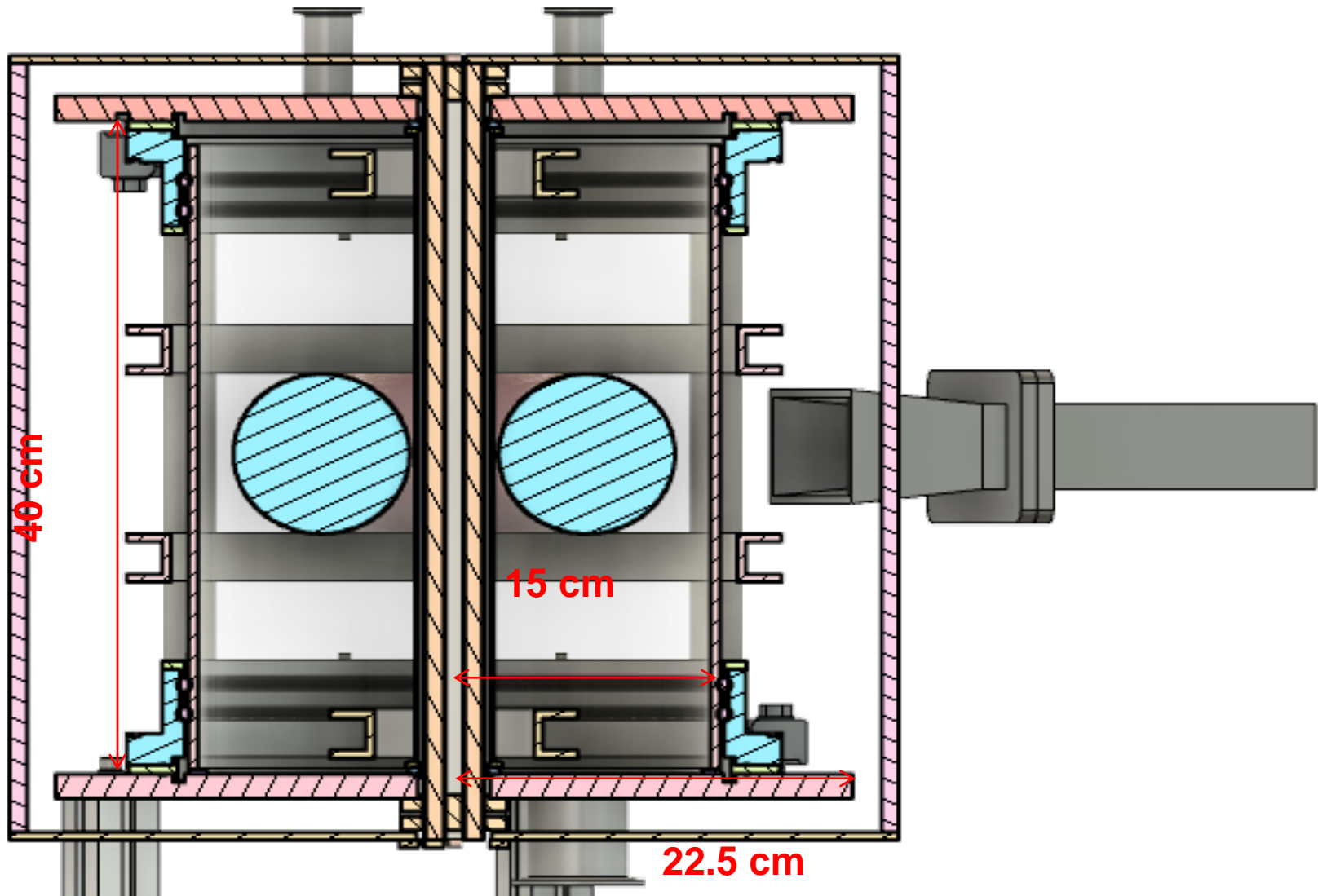




# 可拆式視窗



# Flange of the vacuum chamber for the spherical tokamak

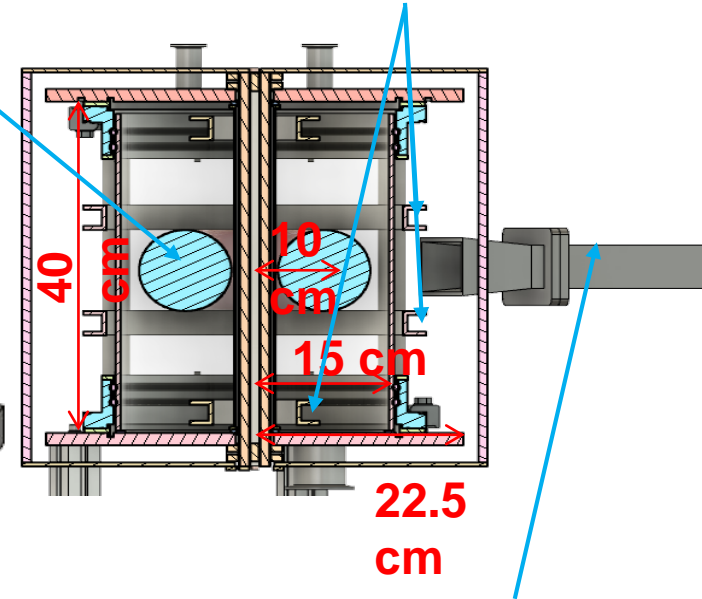


# We need to work with a vacuum system



Vertical-field coils

Tokamak plasma



1 kW, 2.45 GHz  
Magnetron

- (1) Feedthrough for conducting current to drive the vertical coil.
- (2) Feedthrough for Rogowski coil.
- (3) Feedthrough for triple probe.

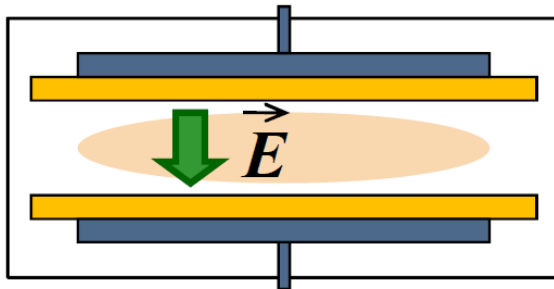
# Plasma will first be generated using capacitive coupling



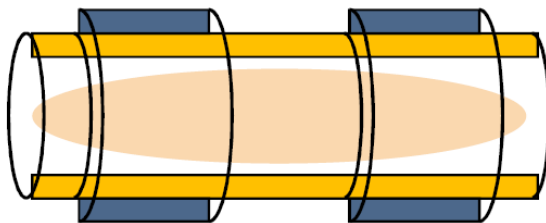
- RF can interact with plasma inductively or capacitively.

## Capacitively coupled

planar

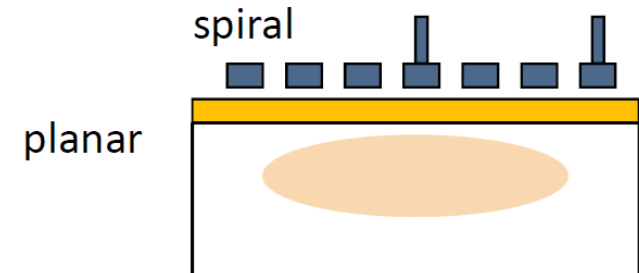
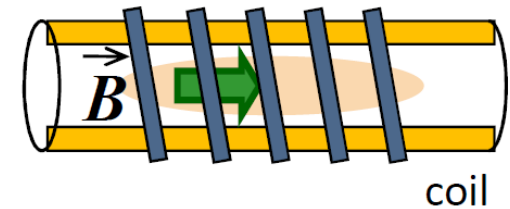


coaxial

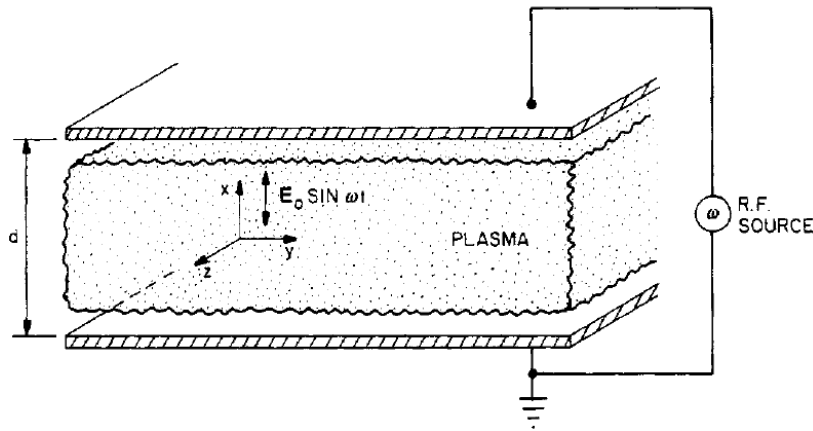


## Inductively coupled

coaxial



# Capacitive RF coupling plasma without magnetic fields



$$\vec{F} = m \vec{a} = -\nu_c m \vec{v} - e \vec{E}$$

$$m \frac{dv_y}{dt} + m\nu_c v_y = 0$$

$$v_y(t) = v_{y0} \exp(-\nu_c t)$$

$$m \frac{d^2 x}{dt^2} + m\nu_c \frac{dx}{dt} = eE_0 \sin(\omega t)$$

$$x = C_1 \sin(\omega t) + C_2 \cos(\omega t)$$

$$C_1 = -\frac{eE_0}{m} \frac{1}{\omega^2 + \nu_c^2}$$

$$C_2 = -\frac{\nu_c eE_0}{\omega m} \frac{1}{\omega^2 + \nu_c^2}$$

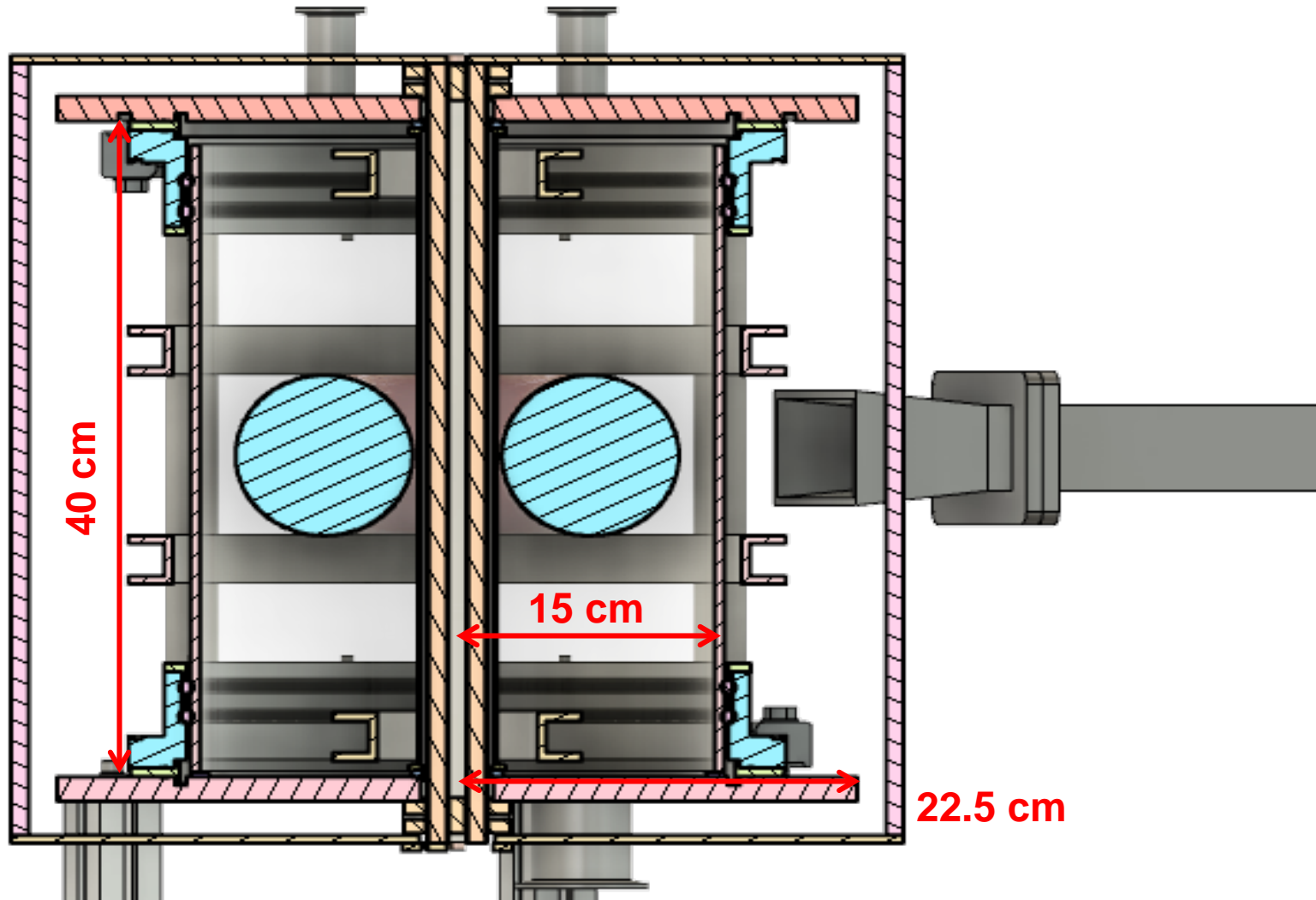
$$v_x(t) = -\frac{eE_0 \omega}{m(\omega^2 + \nu_c^2)} \left[ \cos(\omega t) - \frac{\nu_c}{\omega} \sin(\omega t) \right]$$

$$P = \frac{dW}{dt} = eE_0 \sin(\omega t) v_x$$

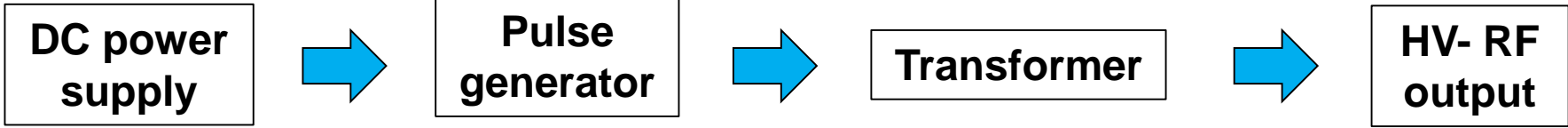
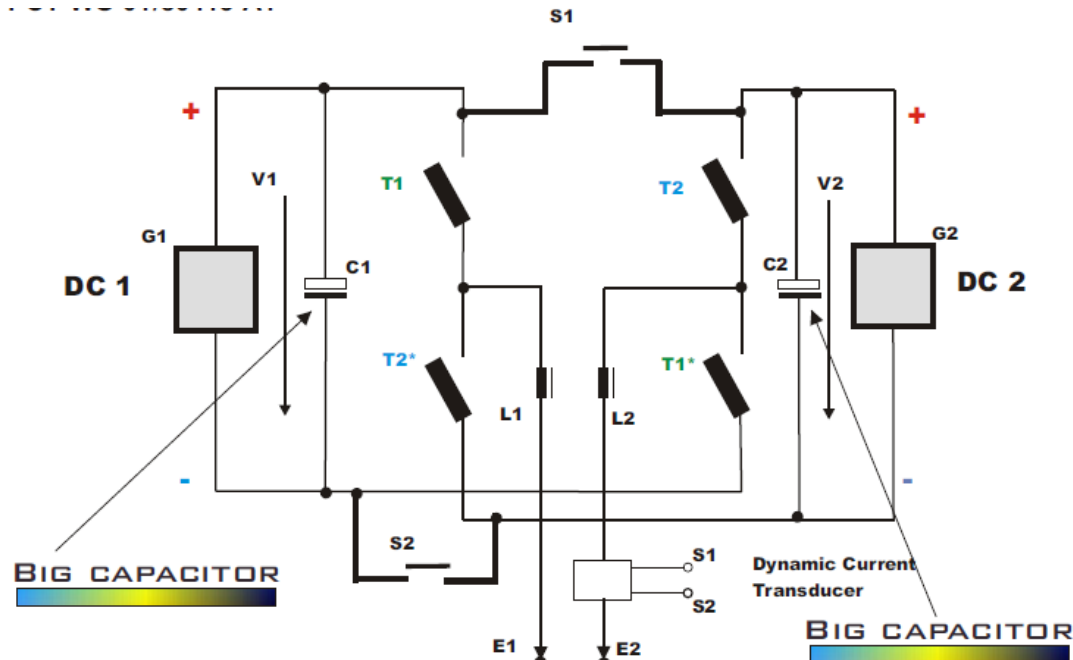
$$\bar{P}_{\text{tot}} = n_e \bar{P} = \frac{1}{4} \epsilon_0 E_0^2 \frac{2n_e e^2}{m \epsilon_0} \frac{\nu_c}{\omega^2 + \nu_c^2}$$



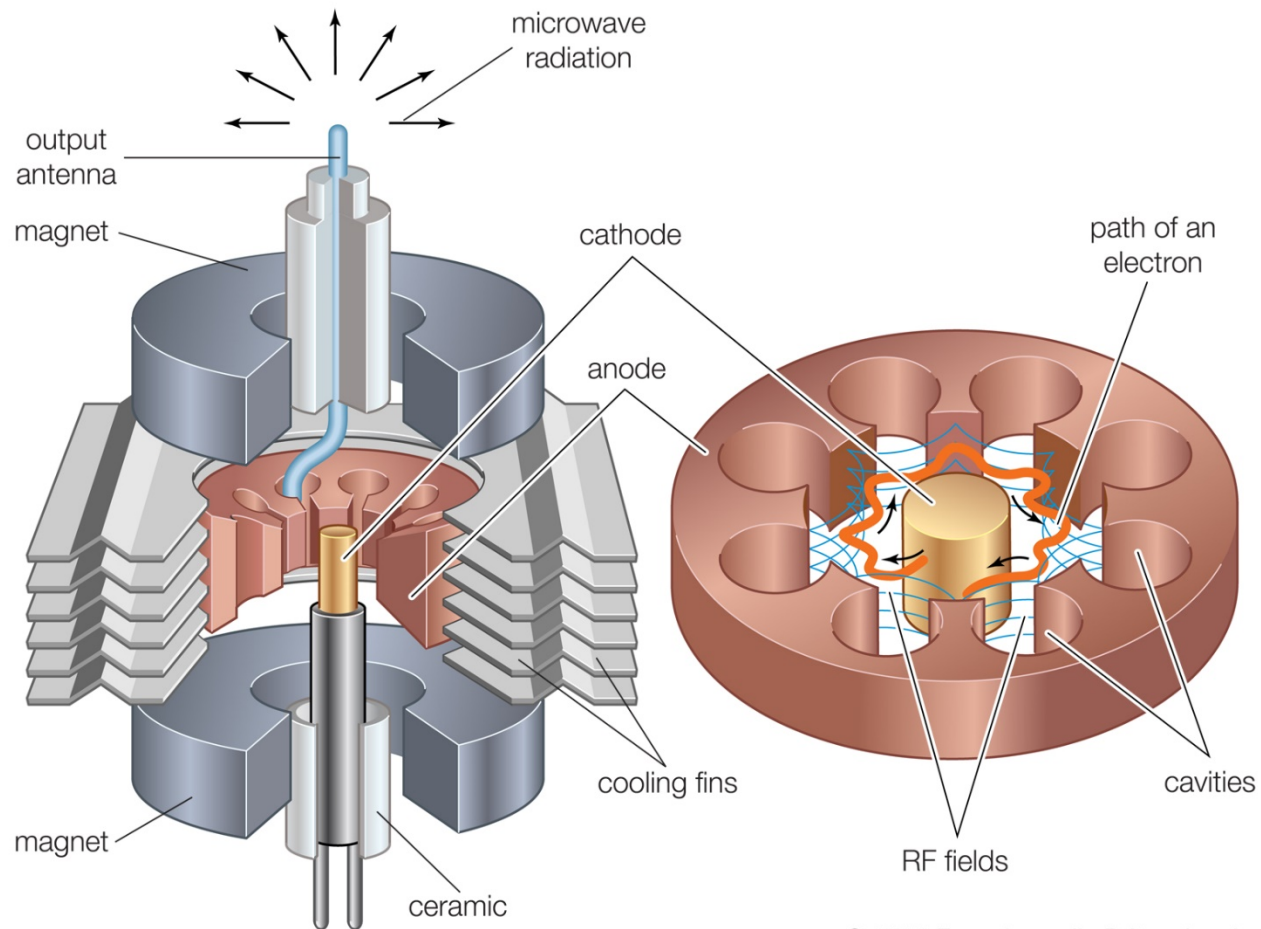
**High voltage electrode inserted from the feedthrough at the bottom of the chamber will be used for CCP**



# A pulse generator will be used to convert a DC voltage to an AC voltage

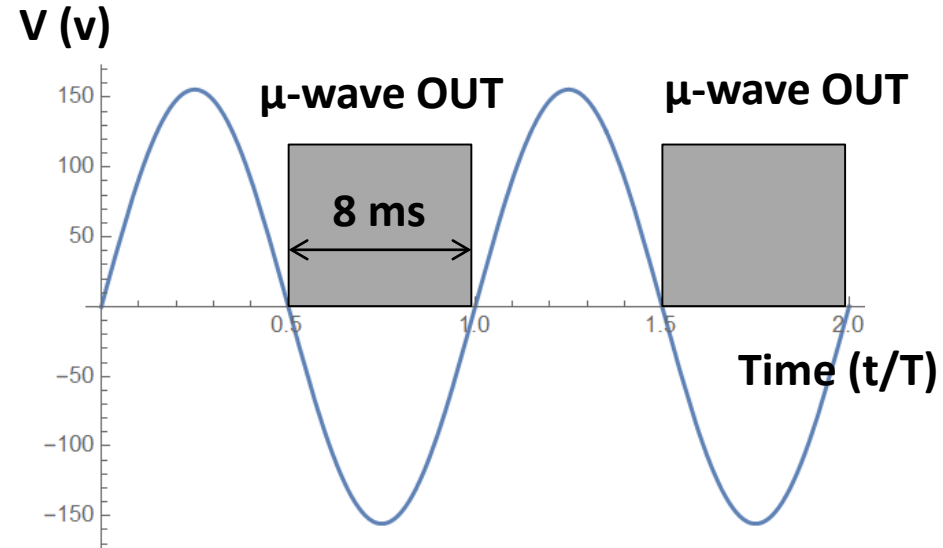
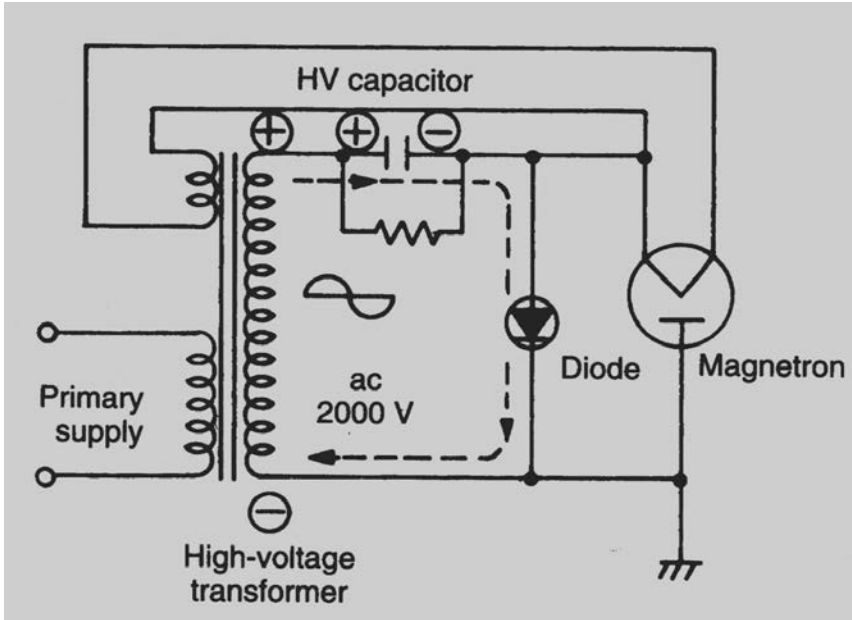


# Internal of a magnetron



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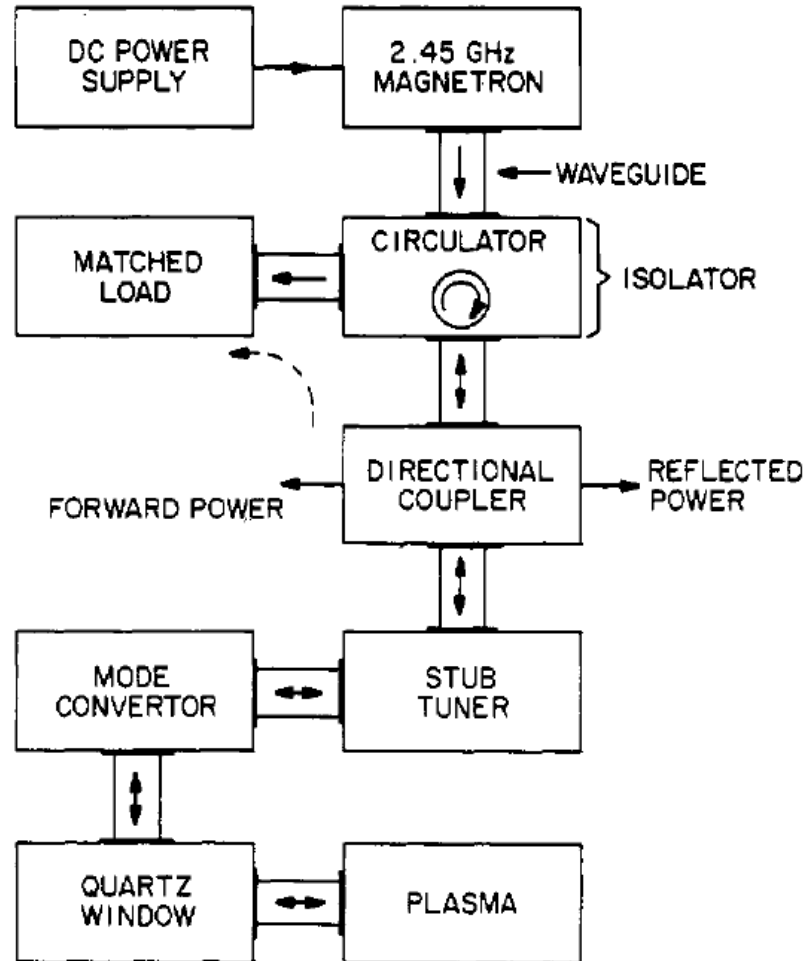
# Microwave is generated in pulses



$$T = \frac{1}{60} = 16.7\text{ms}$$

- The width of the microwave pulses is ~ 8 ms.

# Electron cyclotron resonance (ECR) microwave systems

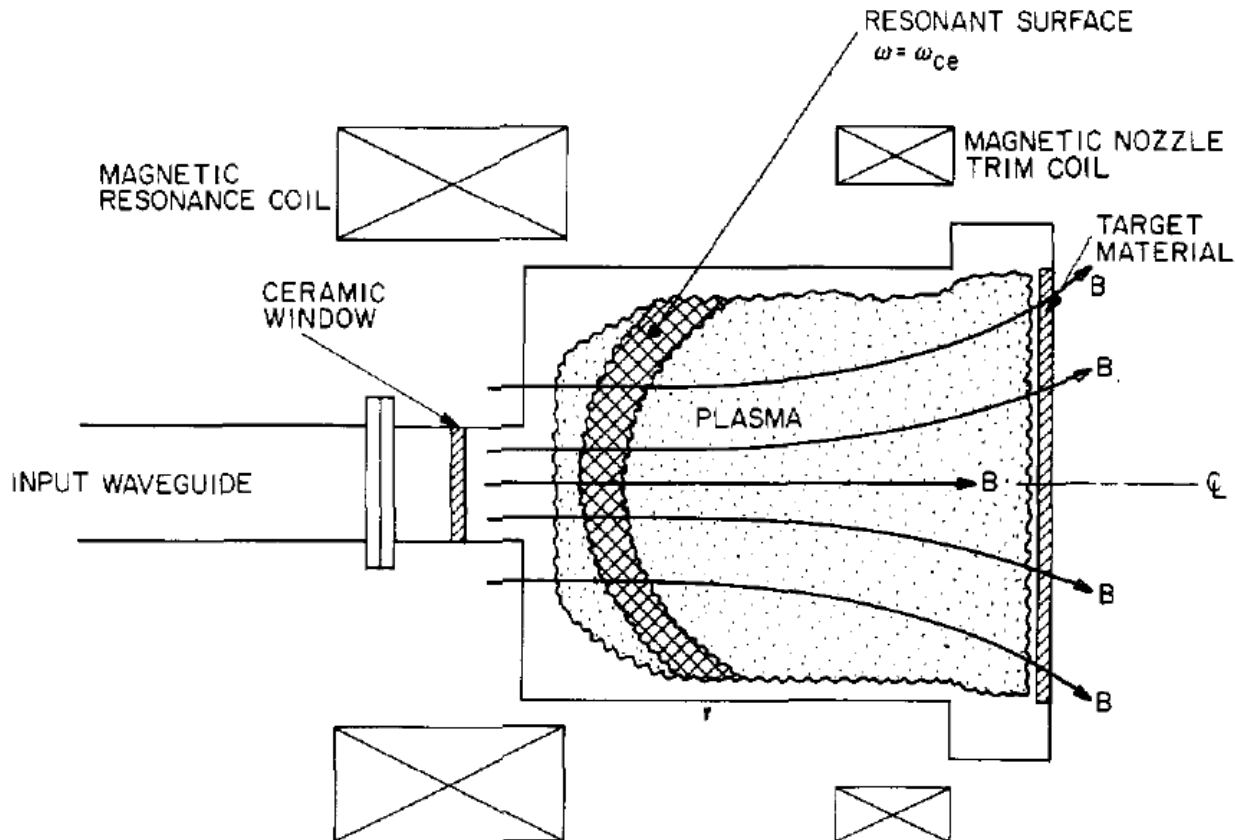


microwave systems

# Strong absorption occurs when the frequency matches the electron cyclotron frequency



- Electron cyclotron resonance heating (ECH, ECR heating)



# Electrons keep getting accelerated when a electric field rotates in electron's gyrofrequency



$$m_e \frac{d\vec{v}}{dt} = -\frac{e}{c} \vec{v} \times \vec{B} - e \vec{E} \quad \vec{B} = B_0 \hat{z} \quad \vec{E} = E_0 [\hat{x} \cos(\omega t) + \hat{y} \sin(\omega t)]$$

$$m_e \dot{v}_x = -\frac{e}{c} B v_y + E_0 \cos(\omega t)$$

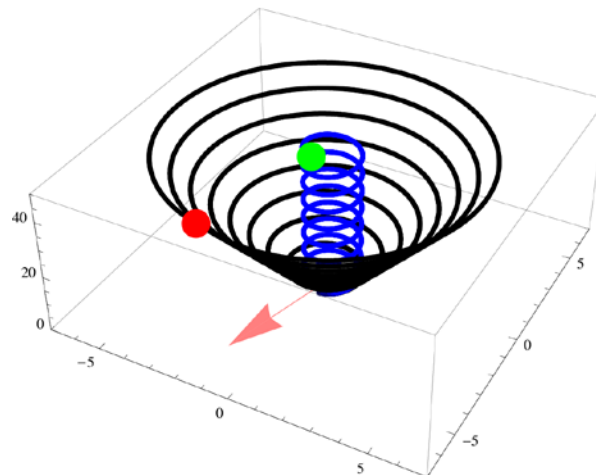
$$m_e \dot{v}_y = \frac{e}{c} B v_x + E_0 \sin(\omega t)$$

$$m_e \dot{v}_z = 0$$

$$\omega_{ce} = \frac{eB}{m_e c}$$

$$\ddot{v}_x = -\omega_{ce}^2 v_x - \frac{E_0}{m_e} (\omega_{ce} + \omega) \cos(\omega t)$$

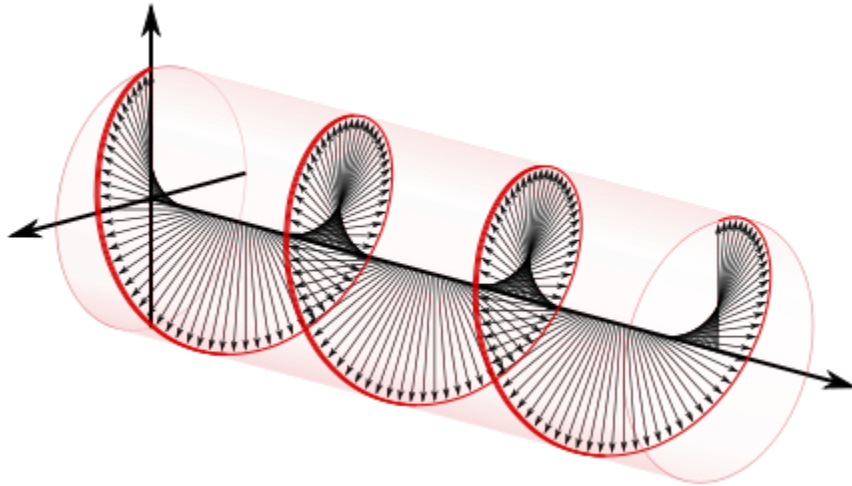
$$\ddot{v}_y = -\omega_{ce}^2 v_y + \frac{E_0}{m_e} (\omega_{ce} + \omega) \sin(\omega t)$$



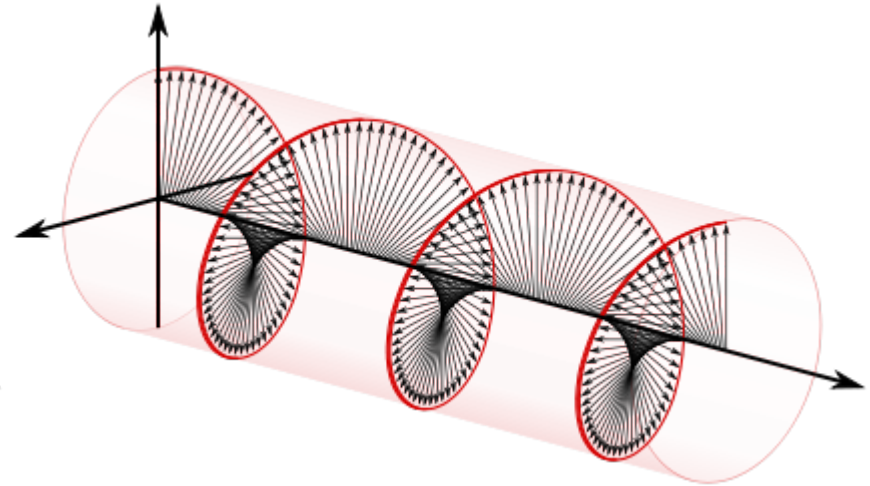
# Electric field in a circular polarized electromagnetic wave keeps rotating as the wave propagates



- Right-handed polarization



- Left-handed polarization





# A magnetic field of 0.0876 T is needed for ECH



$$\omega_{ce} = \frac{eB}{m_e c} \equiv \omega = 2\pi \times 2.45 \text{ GHz}$$

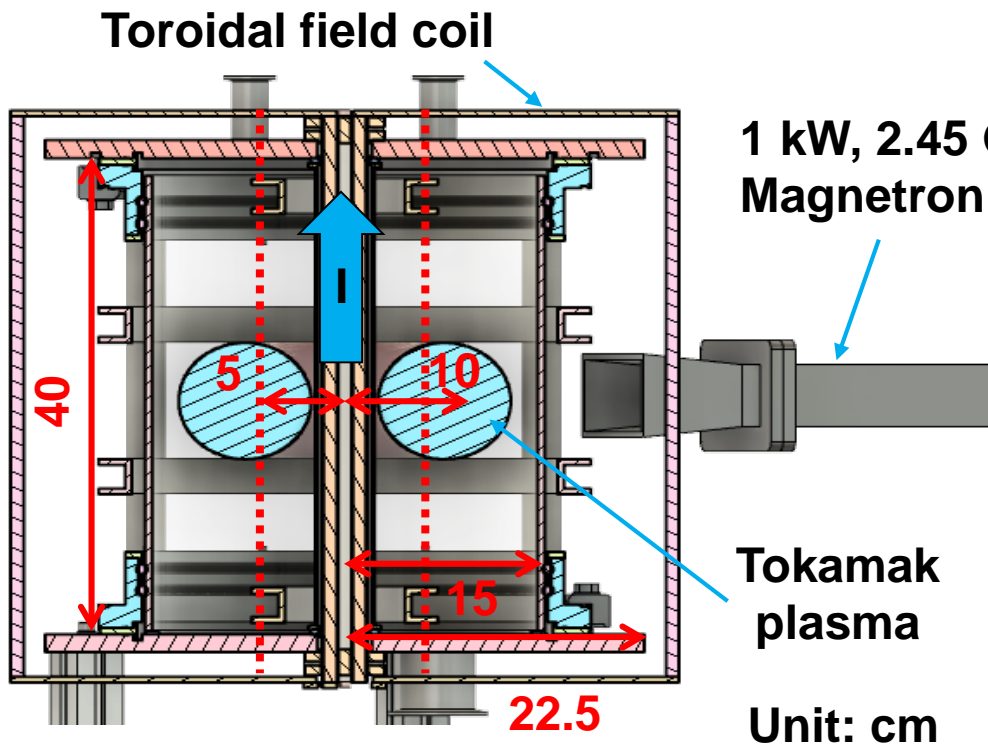
$$B = \frac{2\pi \times 2.45 \times 10^9 m_e c}{e} = 876 \text{ G} = 0.0876 \text{ T}$$

$$B = \frac{\mu_0 I}{2\pi r}$$

$$I = \frac{2\pi r B}{\mu_0} = \frac{2\pi r B}{4\pi \times 10^{-7}}$$

$$= 5B_{(T)} r_{(m)} (\text{MA})$$

$$= 22 \text{ kA @ 5 cm}$$



- A pulsed-power system will be used to generate the current with a pulse width of 1 ms.

# The 0.1-T magnetic field is sufficient to confine 10-eV Ar ion



$$v = r\omega \quad \frac{1}{2}mv^2 = kT \quad \omega = \frac{eB}{m} \quad r = \frac{\sqrt{2mkT}}{eB}$$

- Larmor radius in mm @ B=0.1 T:

T (eV)	H (1g/mole)	D (2g/mole)	T (3g/mole)	He (4g/mole)	Ar (40g/mole)
1	1.4	2.0	2.5	2.9	9.1
10	4.6	6.5	7.9	9.1	28.9
100	14.4	20.4	25.0	28.9	91.3
1000	45.6	64.5	79.1	91.3	288.7

- The Larmor radius of 1-keV electron @ B=0.1 T is 1.1 mm. Electrons are confined in our system.

• Ar will be used.

# The magnetic field energy of the toroidal field is ~100 J



$$B = \frac{\mu_0 I}{2\pi r}$$

$$E = \int \frac{B^2}{2\mu_0} dv = \int_{r_{\min}}^{r_{\max}} \frac{B^2}{2\mu_0} 2\pi r L dr = \frac{2\pi L \mu_0^2 I^2}{2\mu_0 (2\pi)^2} \int_{r_{\min}}^{r_{\max}} \frac{1}{r^2} r dr = \frac{\mu_0 L I^2}{4\pi} \int_{r_{\min}}^{r_{\max}} \frac{1}{r} dr$$

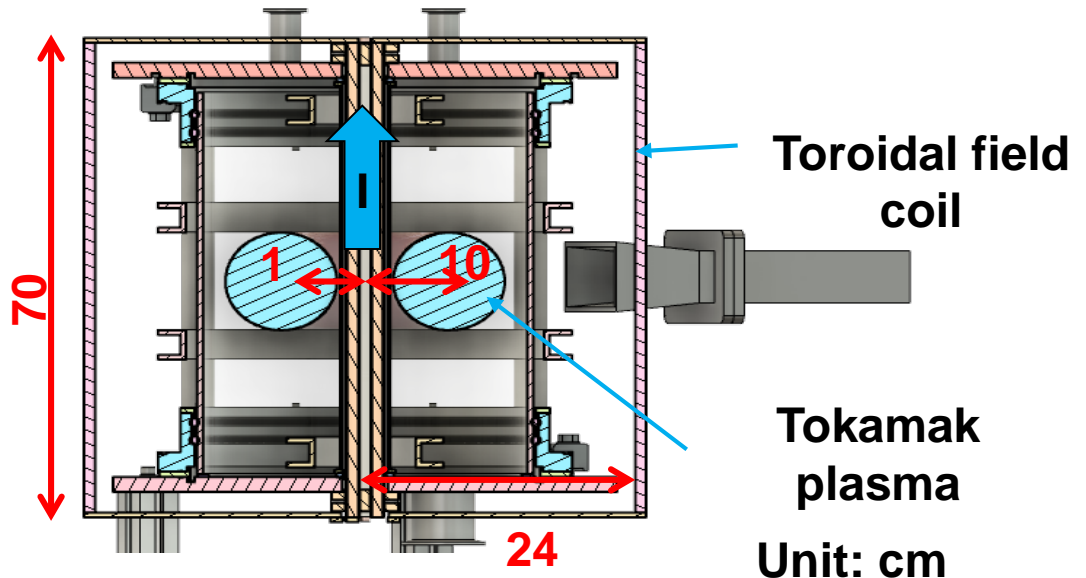
$$= \frac{\mu_0 L I^2}{4\pi} \ln\left(\frac{r_{\max}}{r_{\min}}\right) = 10^{-7} \times 0.7 \times (20 \times 10^3)^2 \ln\left(\frac{24}{1}\right)$$

$$= 89 \text{ J}$$

$$E = \frac{1}{2} L I^2 \quad L = \frac{2E}{I^2}$$

#/ of Turns	I (kA)	L (μH)
1	20	0.45
4	5	7.1
8	2.5	28.5

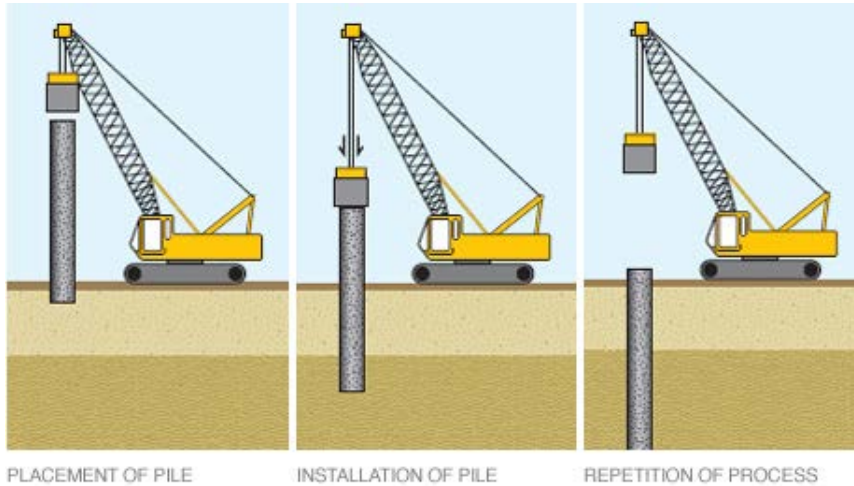
- Measured  $L=15 \mu\text{H}$



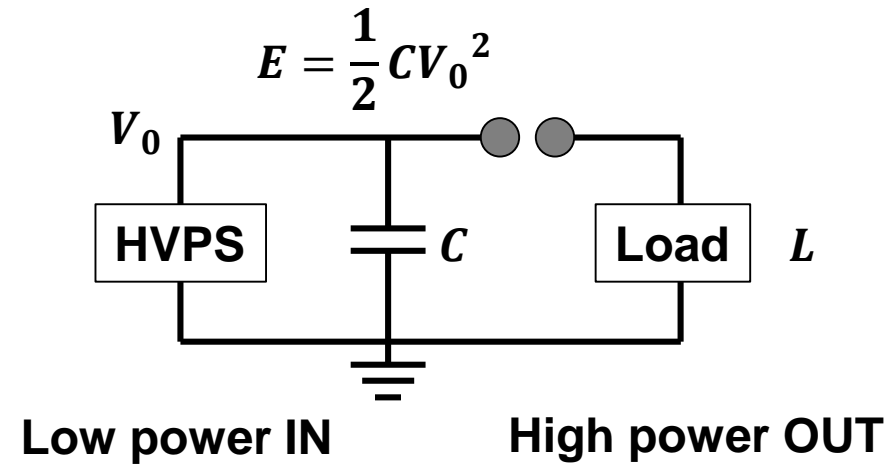
# A pulsed-power system is capable of providing a high-power output



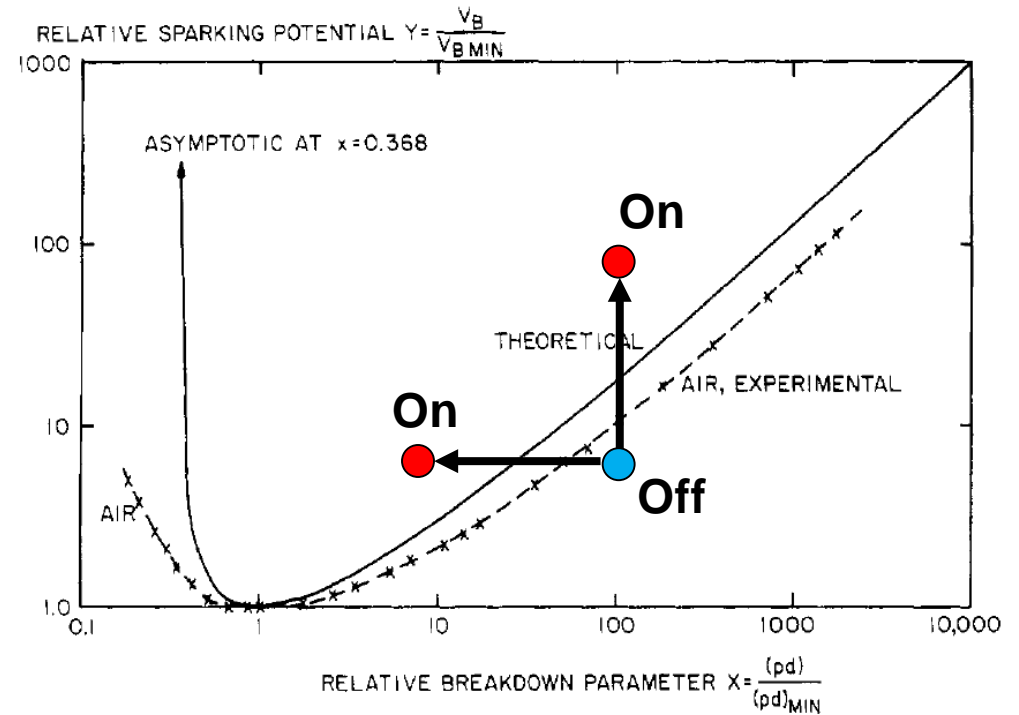
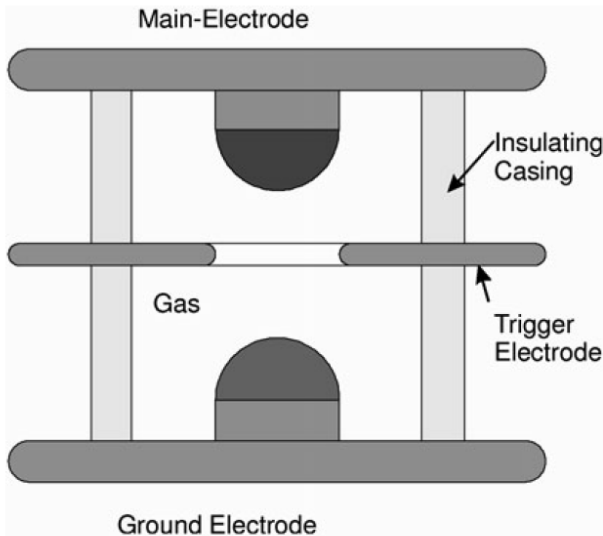
- Driven piles



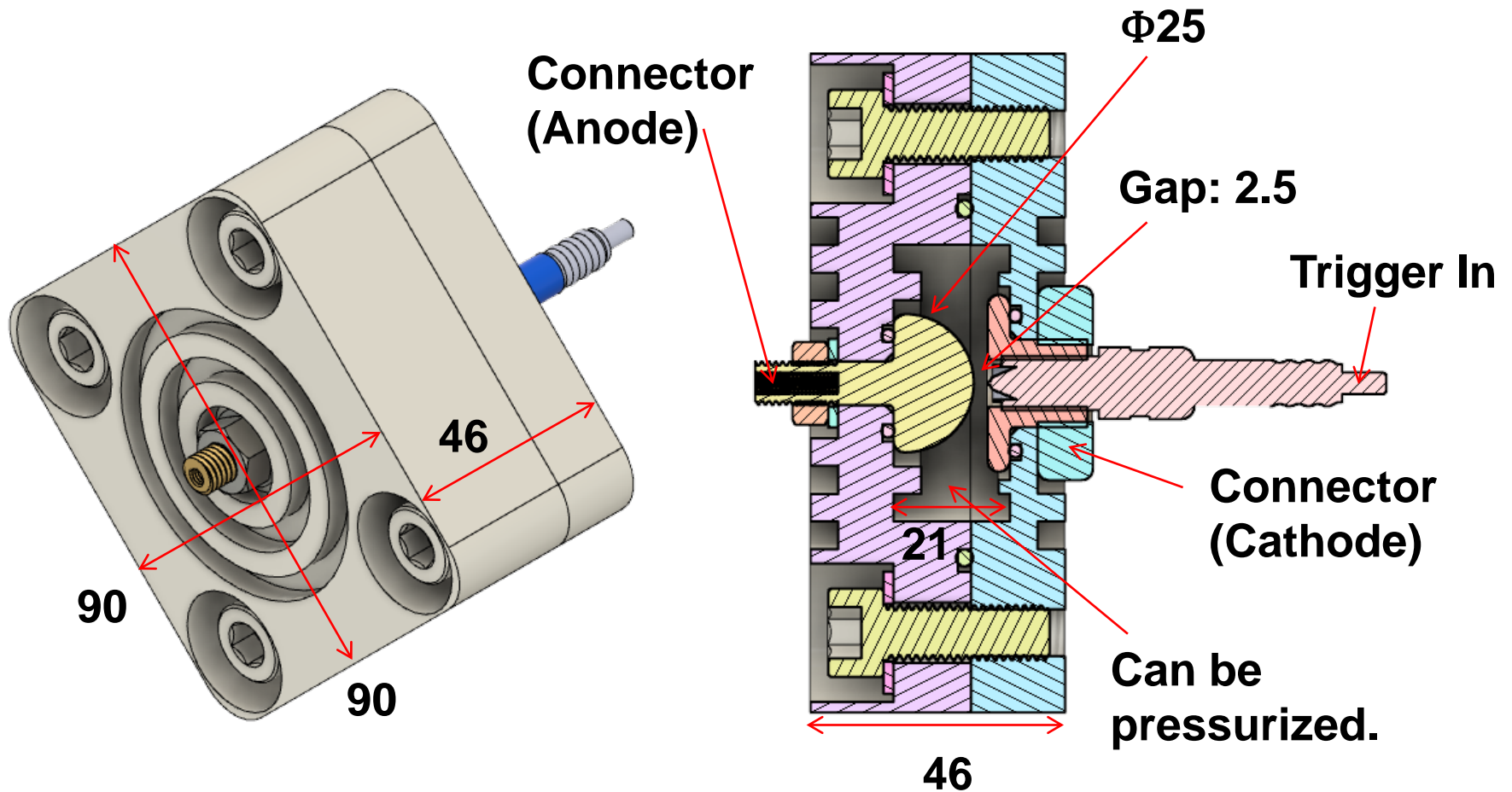
- Capacitive-storage pulsed-power system



# A spark gap switch is closed when electron breakdown occurs

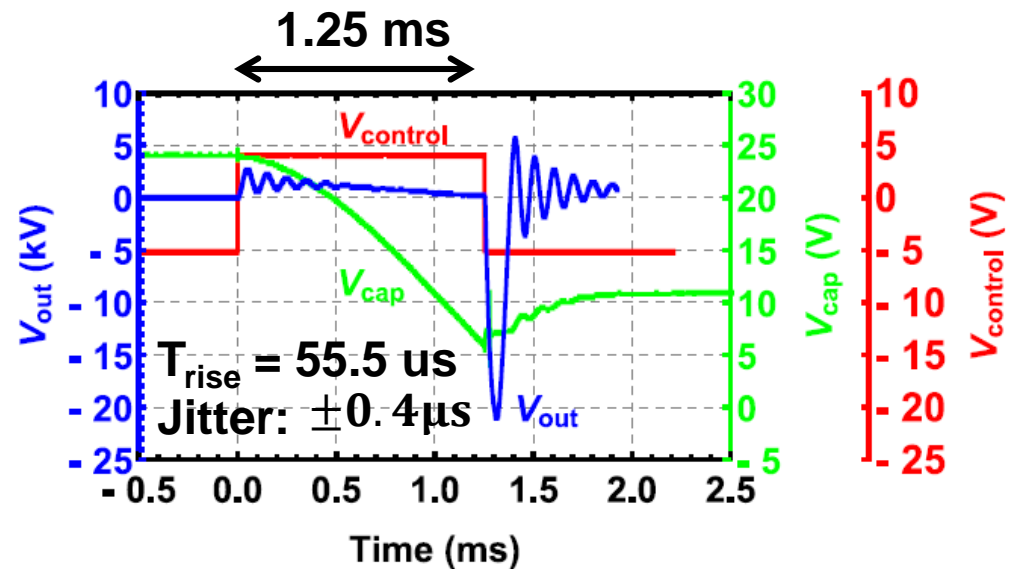
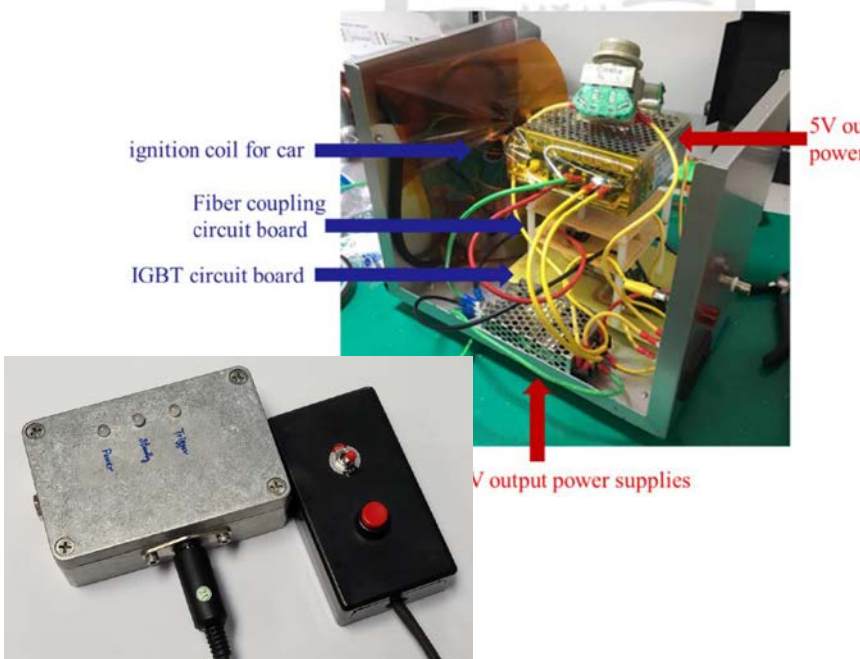
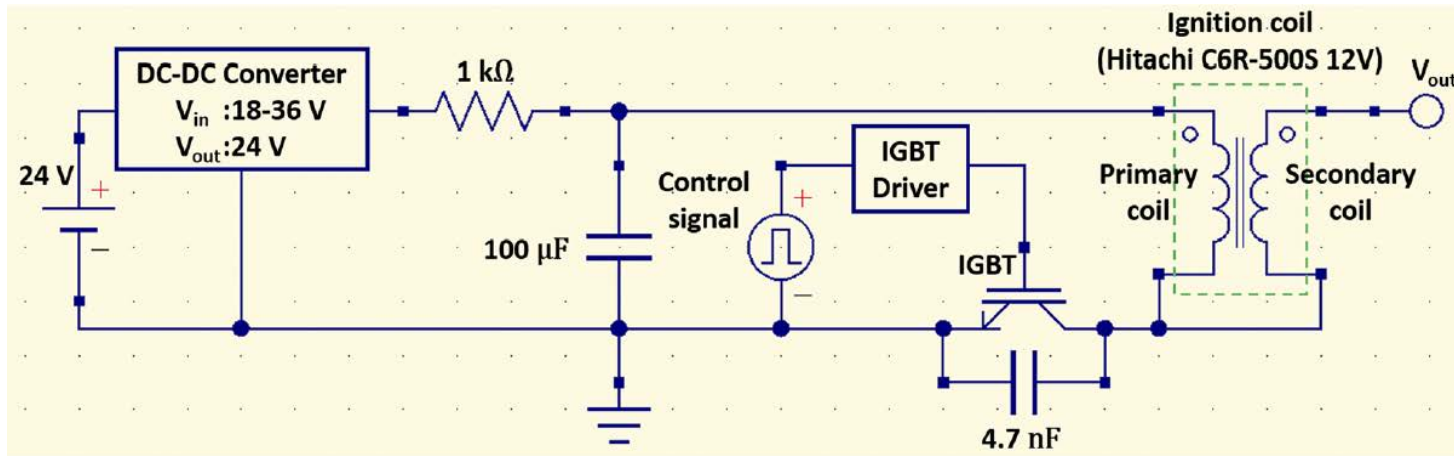


# Trigatron will be used as the controlled-spark gap switch

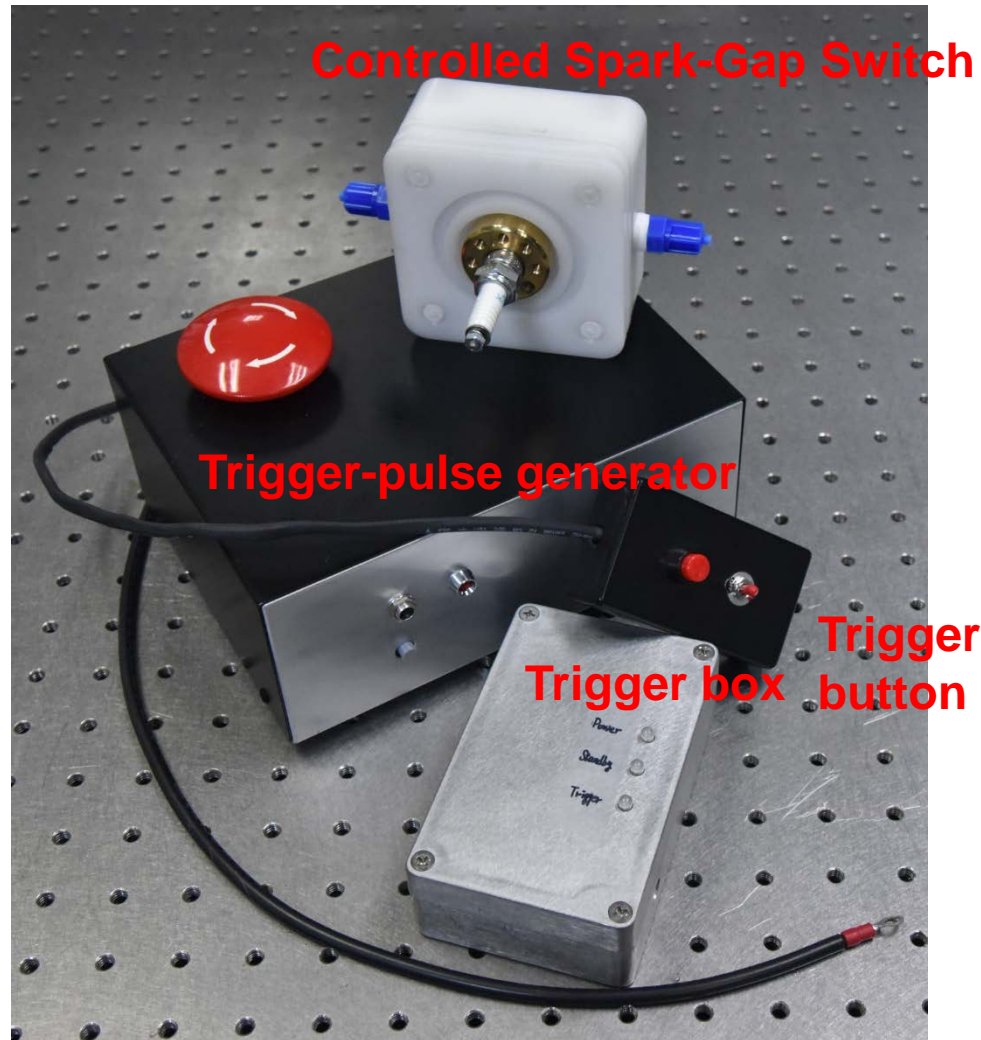


Unit: mm

# A slow trigger pulse generator was built using a ignition coil for cars



# The controlled spark-gap switch

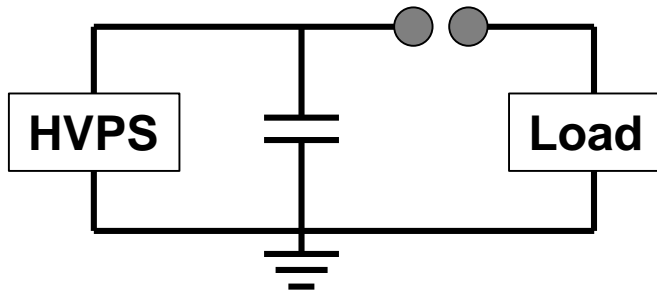




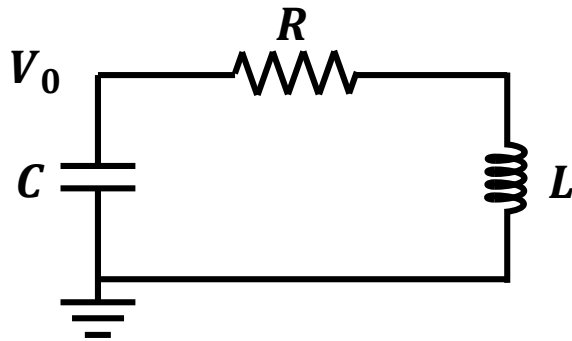
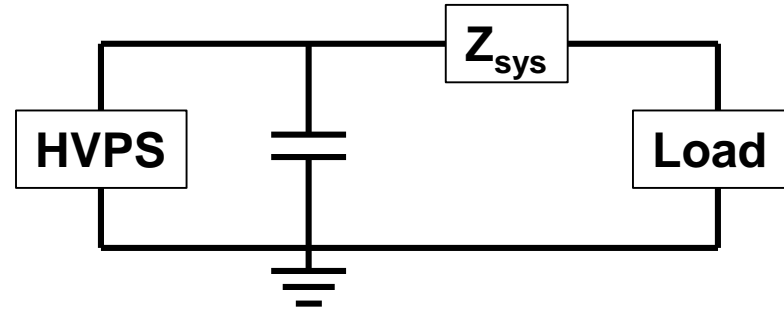
# A simple pulsed-power system is a RLC circuit



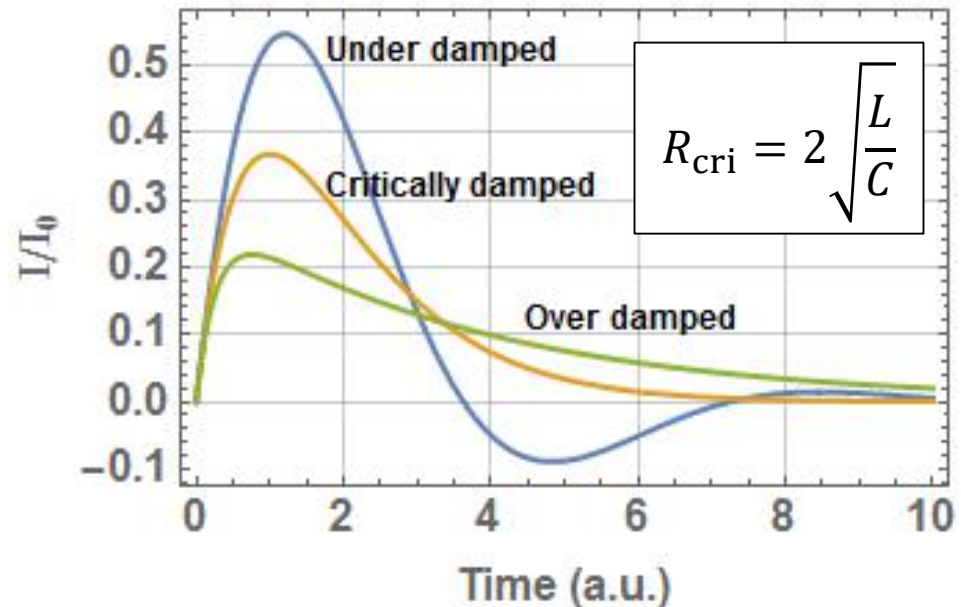
- Before discharge



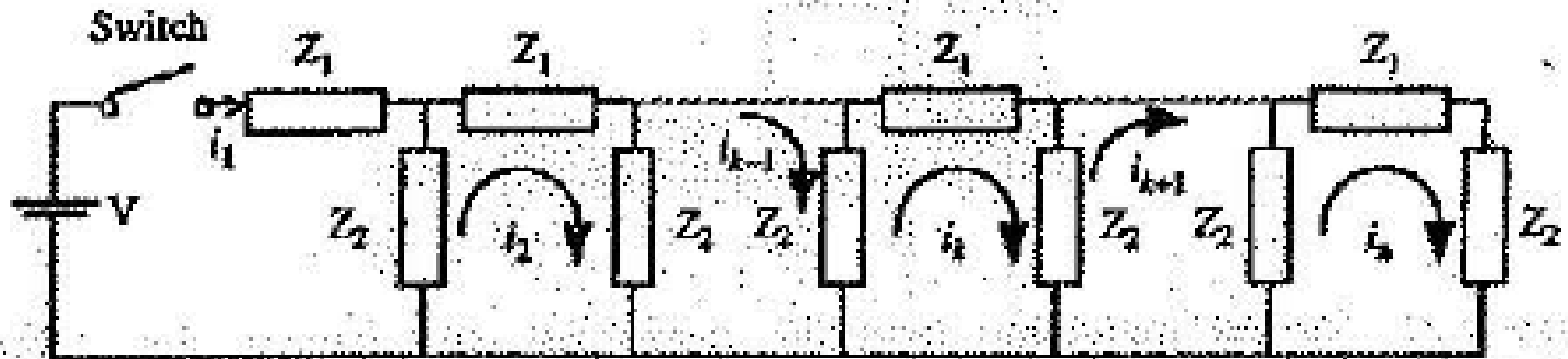
- After discharge



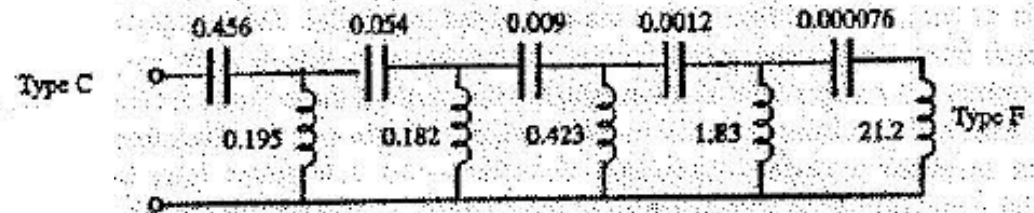
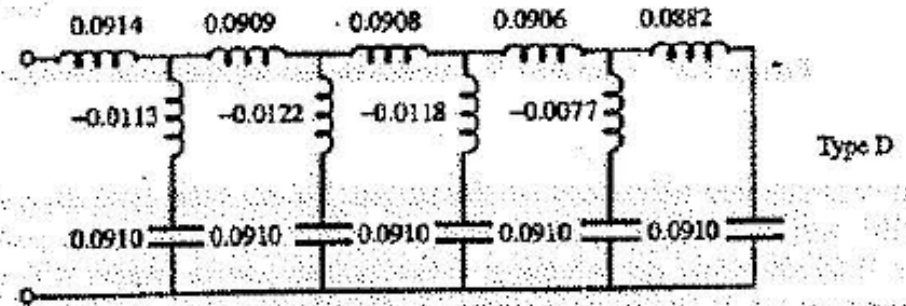
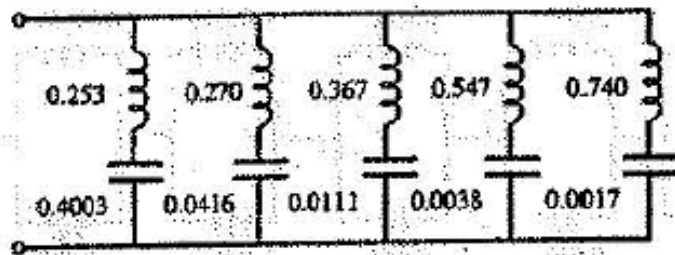
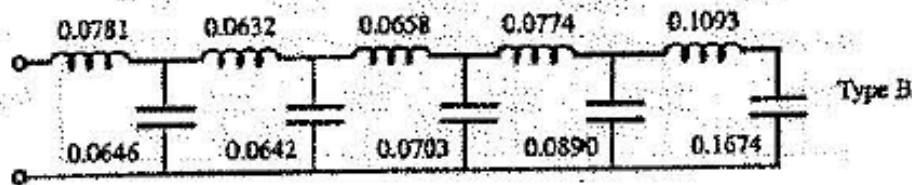
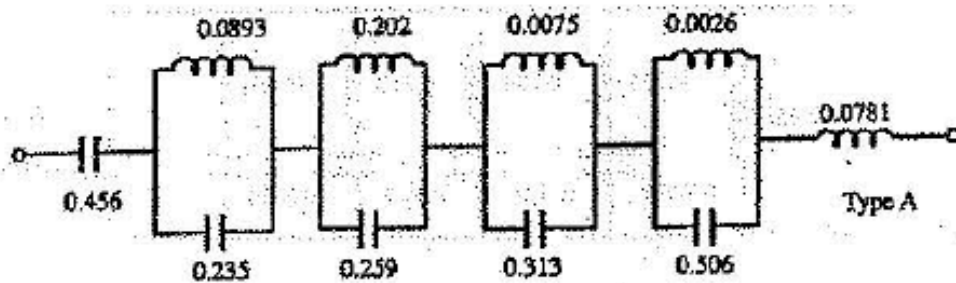
- How can we generate a square current pulse?



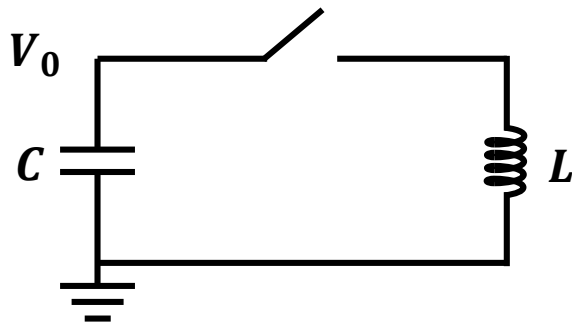
# Pulse-forming network (PFN)



# Different type of PFN



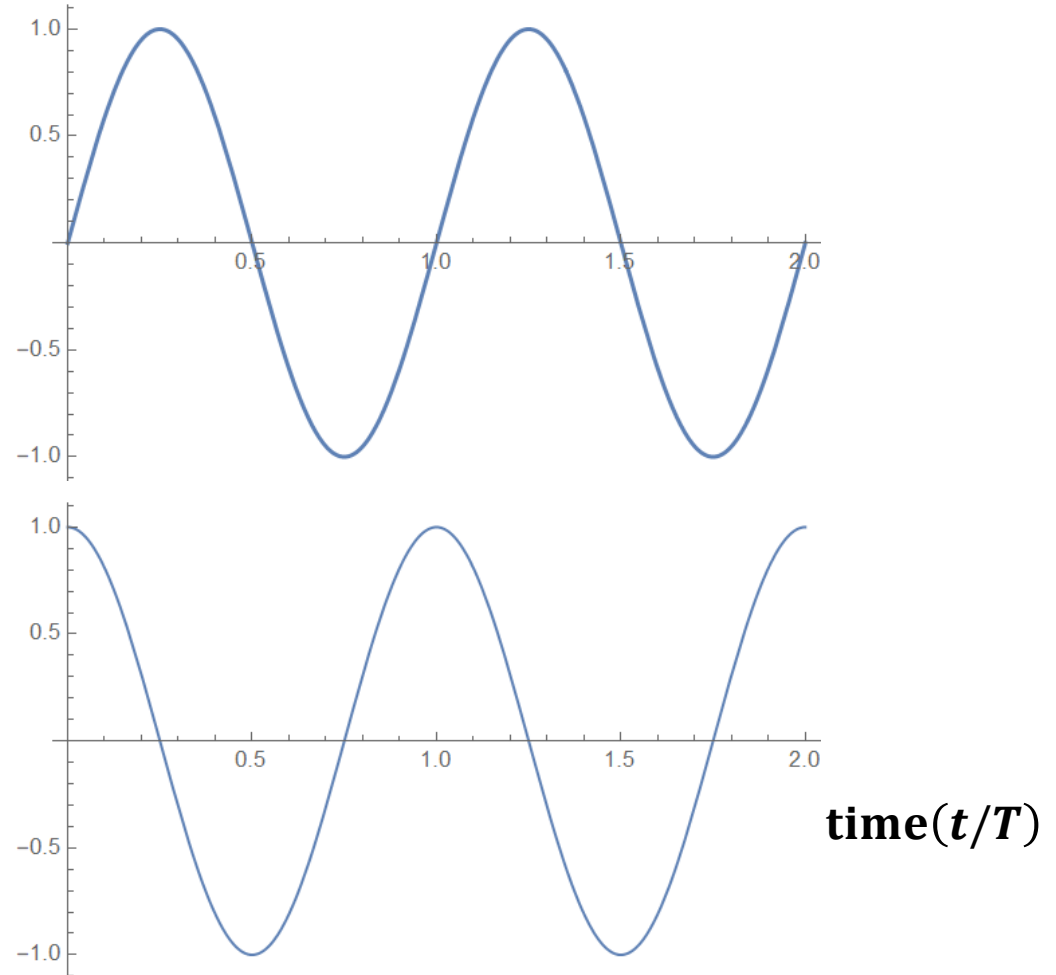
# The current output of a LC circuit is a basis of Fourier series



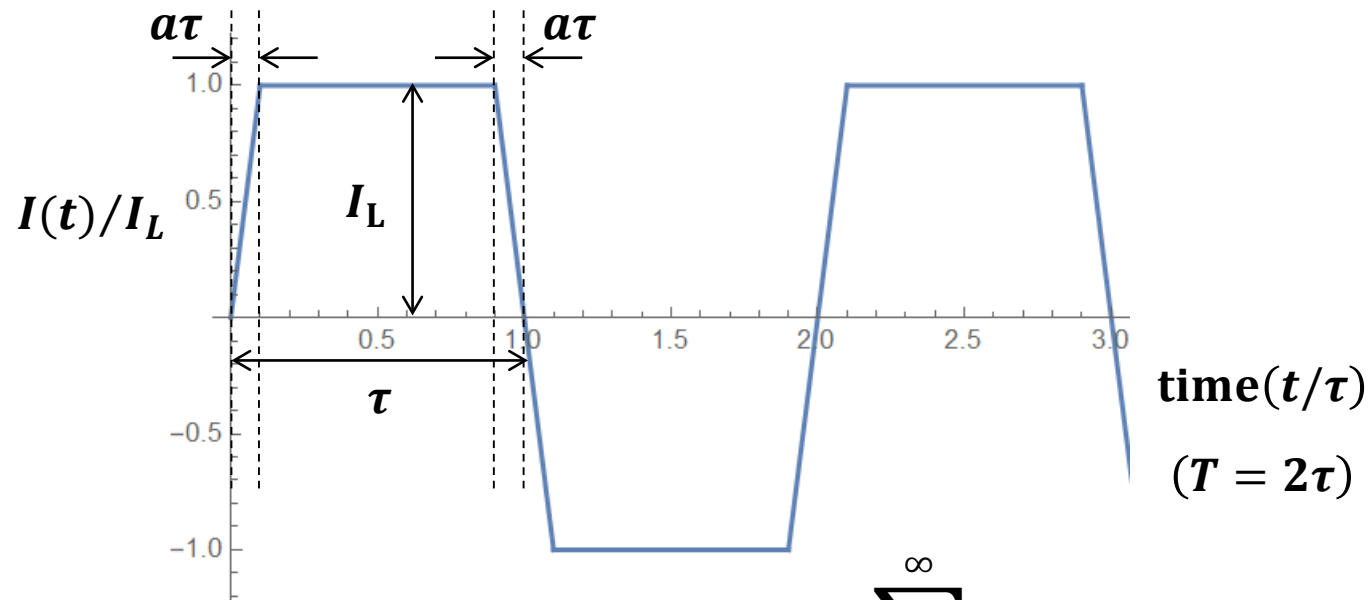
$$I(t) = V_0 \sqrt{\frac{C}{L}} \sin\left(\frac{t}{\sqrt{LC}}\right)$$

$$V(t) = V_0 \cos\left(\frac{t}{\sqrt{LC}}\right)$$

$$Z = \sqrt{\frac{L}{C}} \quad \omega = \frac{1}{\sqrt{LC}}$$



# A trapezoidal wave can be expressed by Fourier series (Guillemin's method)



$$\frac{i(t)}{I_L} = \frac{t}{a\tau}, \quad 0 \leq t \leq a\tau$$

$$\frac{i(t)}{I_L} = 1, \quad a\tau \leq t \leq \tau - a\tau$$

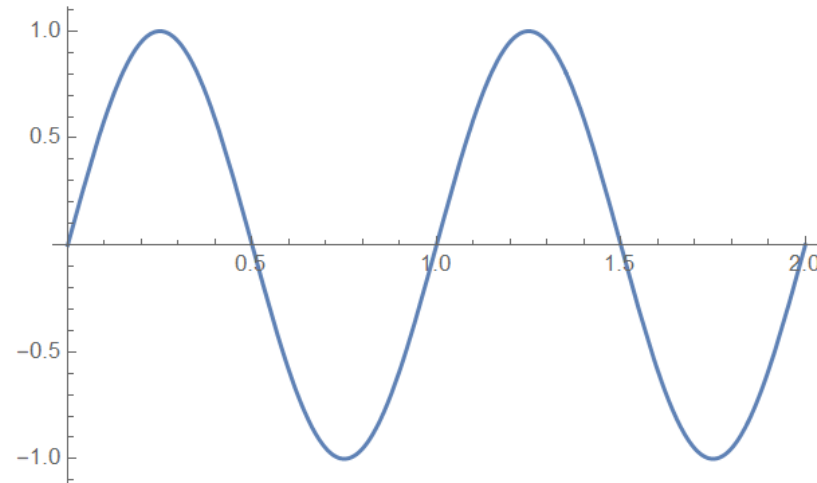
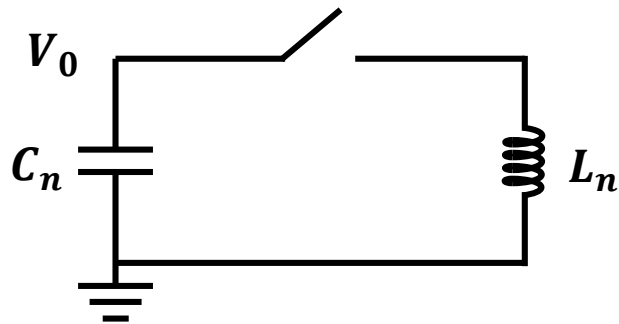
$$\frac{i(t)}{I_L} = \frac{\tau - t}{a\tau}, \quad \tau - a\tau \leq t \leq \tau$$

$$i(t) = I_L \sum_{n=1}^{\infty} b_n \sin\left(\frac{n\pi t}{\tau}\right)$$

$$\text{where } b_n = \frac{2}{\tau} \int_0^{\tau} \frac{i(t)}{I_L} \sin\left(\frac{n\pi t}{\tau}\right) dt$$

$$b_n = \frac{4}{n\pi} \frac{\sin(n\pi a)}{n\pi a}, \quad \text{where } n = 1, 3, 5, \dots$$

# The required inductance and capacitance are obtained by comparing LC output with the Fourier series



$$I_n(t) = V_0 \sqrt{\frac{C_n}{L_n}} \sin\left(\frac{t}{\sqrt{L_n C_n}}\right)$$

$$i(t) = I_L \sum_{n=1}^{\infty} b_n \sin\left(\frac{n\pi t}{\tau}\right)$$

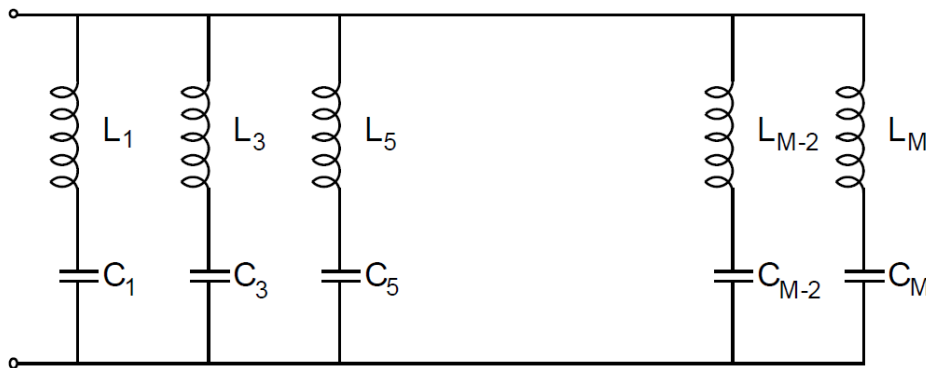
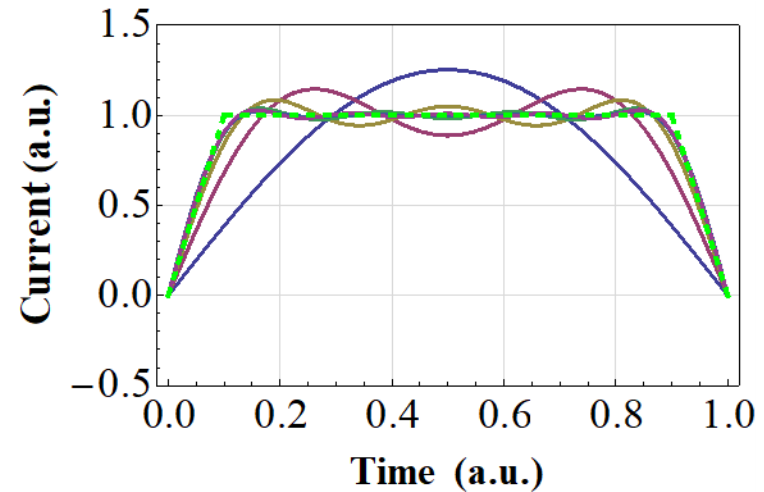
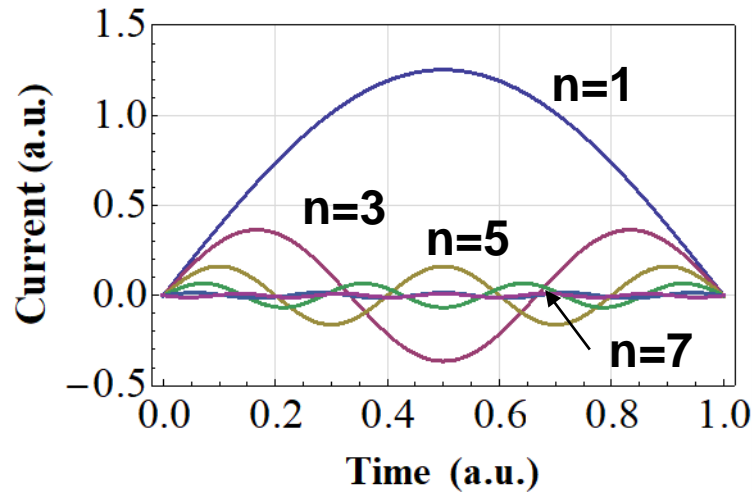
$$b_n = \frac{4}{n\pi} \frac{\sin(n\pi a)}{n\pi a}, \text{ where } n = 1, 3, 5, \dots$$

$$L_n = \frac{Z_n \tau}{n\pi b_n} = \frac{V}{I_L} \frac{\tau}{n\pi b_n}$$

$$C_n = \frac{\tau b_n}{n\pi Z_n} = \frac{I_L}{V} \frac{\tau b_n}{n\pi}$$

$$Z_n = \frac{V}{I_L}$$

# A trapezoidal current output can be generated using Guillemin's pulse-forming networks

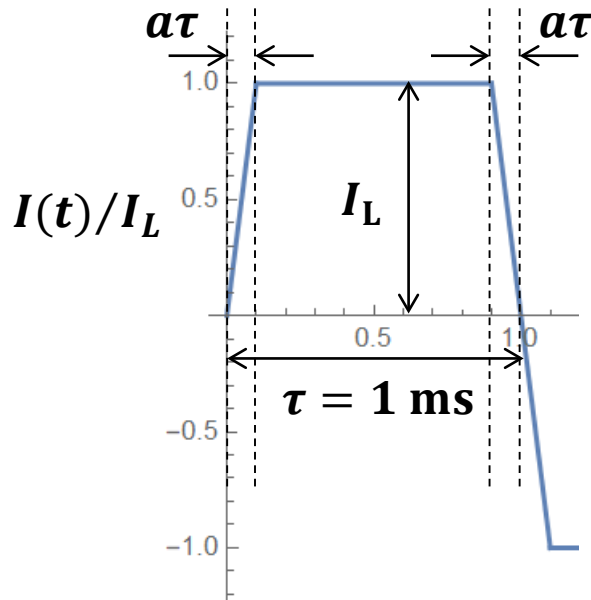


$$I(t) = I_L \sum b_n \sin\left(\frac{n\pi t}{\tau}\right)$$

$$b_n = \frac{4}{n\pi} \frac{\sin(n\pi a)}{n\pi a}$$

$$L_n = \frac{Z\tau}{n\pi b_n} \quad C_n = \frac{\tau b_n}{n\pi Z} \quad Z = \frac{V}{I_L}$$

# Fourier components of $\tau=1$ ms, $a=0.1$



time( $t/\tau$ )  
( $T = 2\tau$ )

$$i(t) = I_L \sum_{n=1}^{\infty} b_n \sin\left(\frac{n\pi t}{\tau}\right)$$

$$b_n = \frac{4}{n\pi} \frac{\sin(n\pi a)}{n\pi a}, \text{ where } n = 1, 3, 5, \dots$$

n	#/
b1	1.2524
b3	0.3643
b5	0.1621
b7	0.069
b9	0.0155



# Coils with 8 turns and a PFN charged to 1 kV will be used



I (kA)	V (kV)		1	2	3	4	5	E (kJ)	% to 100 J
20	2	L(uH)	25.4	26.1	39.3	68.0	228.7	9.0	1.1 %
		C(uF)	3986.5	386.5	103.2	30.4	5.5		
20	1	L(uH)	12.7	14.6	19.6	34.0	114.4	4.5	2.2 %
		C(uF)	7973.0	773.1	206.4	60.9	10.9		
2.5	2	L(uH)	203.3	233.0	314.2	543.7	1830.0	1.1	8.9 %
		C(uF)	498.3	48.3	12.9	3.8	0.7		
2.5	1	L(uH)	101.7	116.5	157.1	271.8	915.0	0.6	17.7 %
		C(uF)	996.6	96.6	25.8	7.6	1.4		

# A ferrite ring will be used to make the inductors



EPCOS Ferrite Ring Ferrite Core, 25.3 (Dia.) x 14.8 x 10mm



RS庫存編號: 212-0910 | 製造零件編號: B64290L0618X035 | 製造商: EPCOS



此圖片僅供參考，請參閱產品詳細資訊及規格

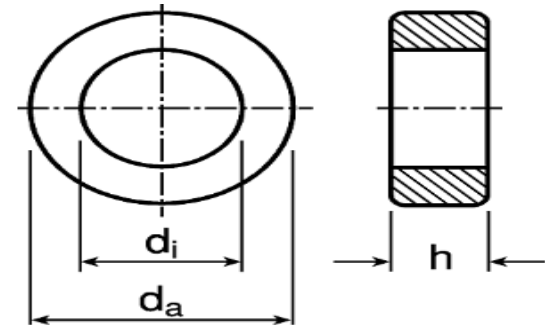
160 現貨庫存，可於6工作日發貨。

單價 (不含稅) / 個 (每包:5個)

TWD35.60 (不含稅)      TWD37.38 (含稅)

單位	Per unit	Per Pack*
5 - 45	TWD35.60	TWD178.00
50 - 245	TWD32.60	TWD163.00
250 - 495	TWD25.40	TWD127.00
500 - 995	TWD24.00	TWD120.00

線上支援



$$d_a = 25.3 \pm 0.5 \text{ mm}$$

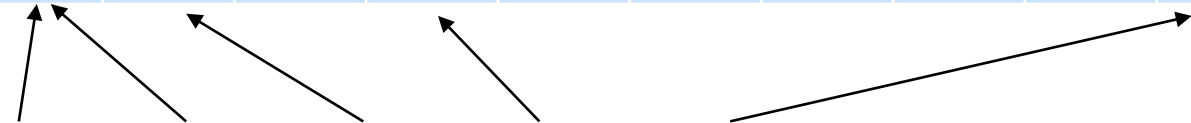
$$d_i = 14.8 \pm 0.5 \text{ mm}$$

$$h = 10. \pm 0.2 \text{ mm}$$

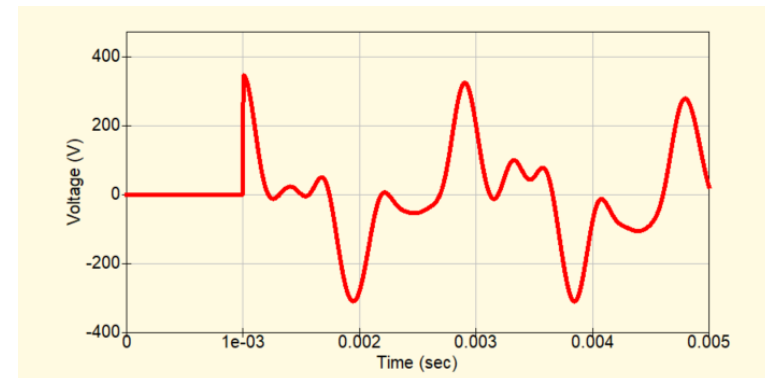
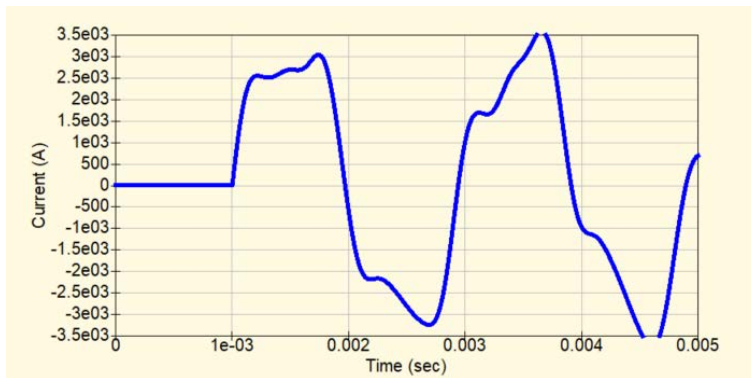
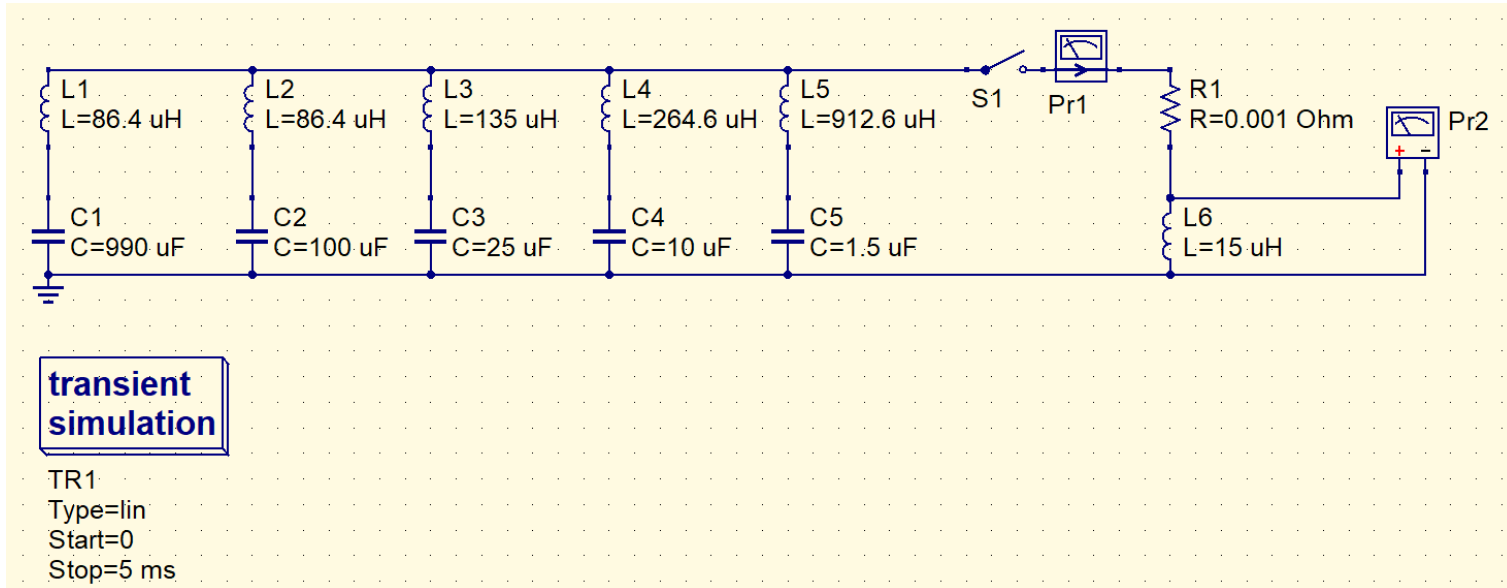
$$\mu_r \approx 5000 \quad L = A_L N^2 \quad A_L = 5400 \pm 25\% \text{ nH}$$

N	1	2	3	4	5	6	7	8	9	10	11	12	13
L(μH)	5.4	21.6	48.6	86.4	135	194	265	346	437	540	653	778	913

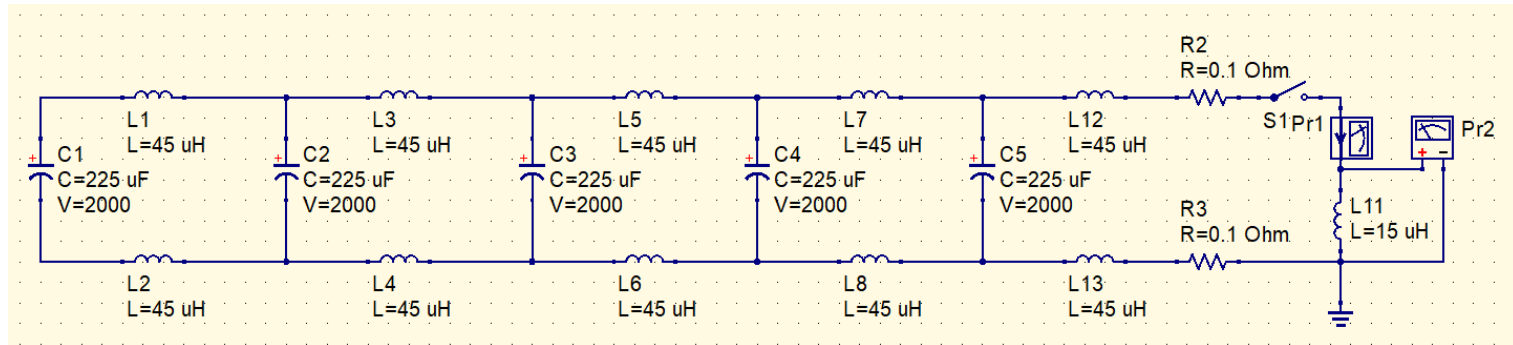
L(uH)	101.7	116.5	157.1	271.8	915.0
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# A square pulse with a flat top of 2.5 kA can be generated



# A simple PFN with constant C and L in all stages can also be used



$$C \equiv \bar{C} = \frac{1}{N} \sum_{n=1}^N C_n = 225 \mu\text{F}$$

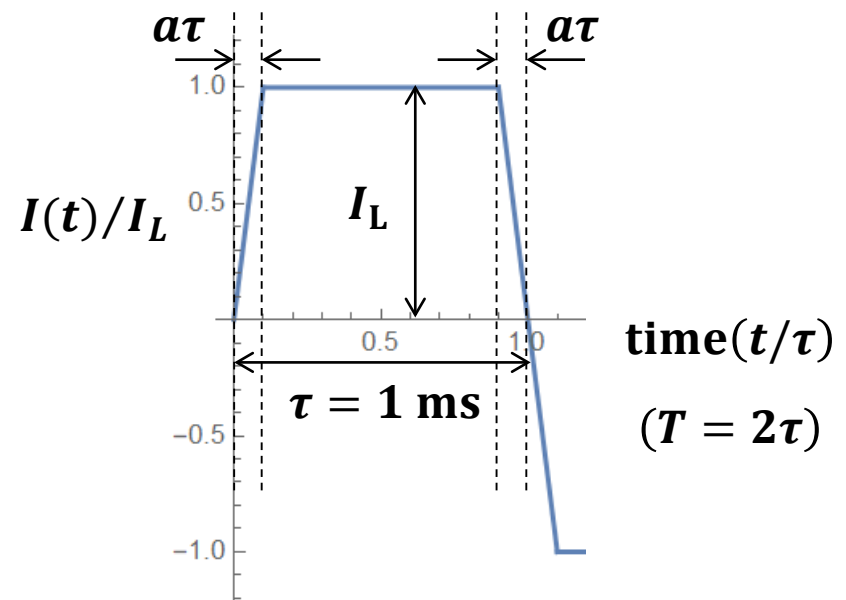
$$L_n = 2nL + L_L \approx 2nL$$

$$\omega_n = \frac{1}{\sqrt{L_n C}} \approx \frac{1}{\sqrt{2nLC}}$$

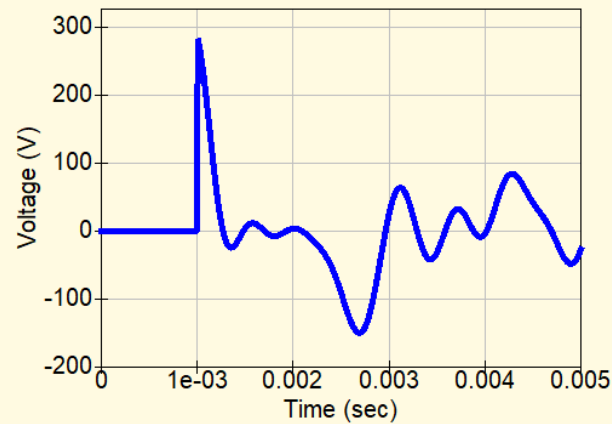
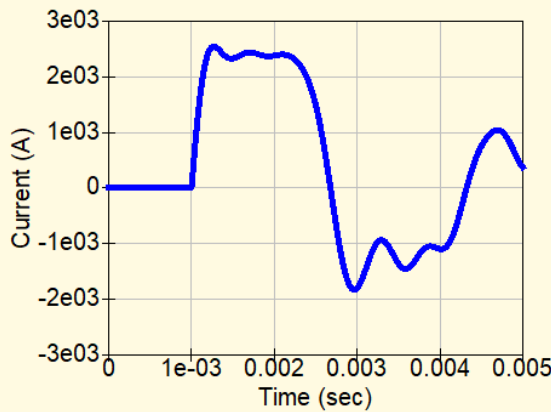
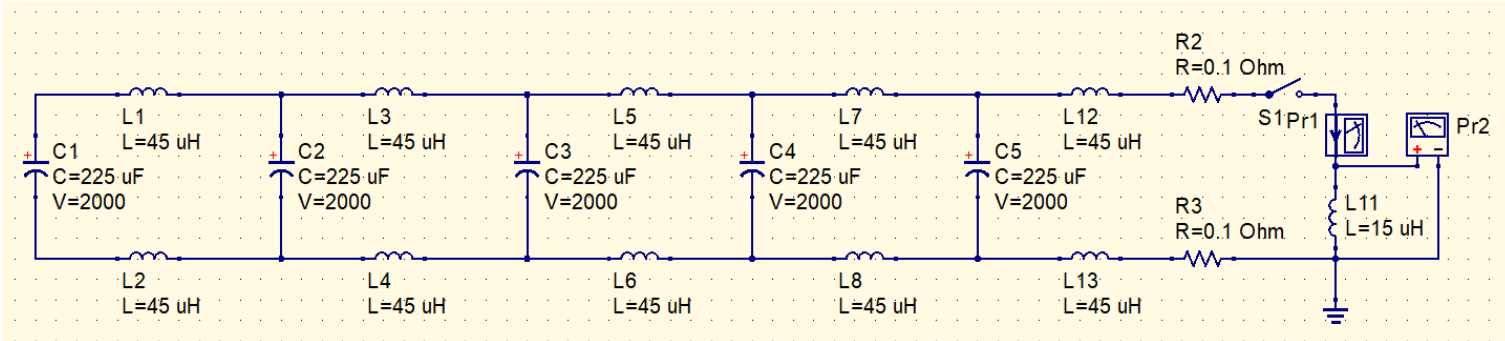
- For 5 stages:

$$\omega_5 = \frac{2\pi}{T} = \frac{\pi}{\tau} = \frac{\pi}{1\text{ms}}$$

$$L = 45 \mu\text{H}$$



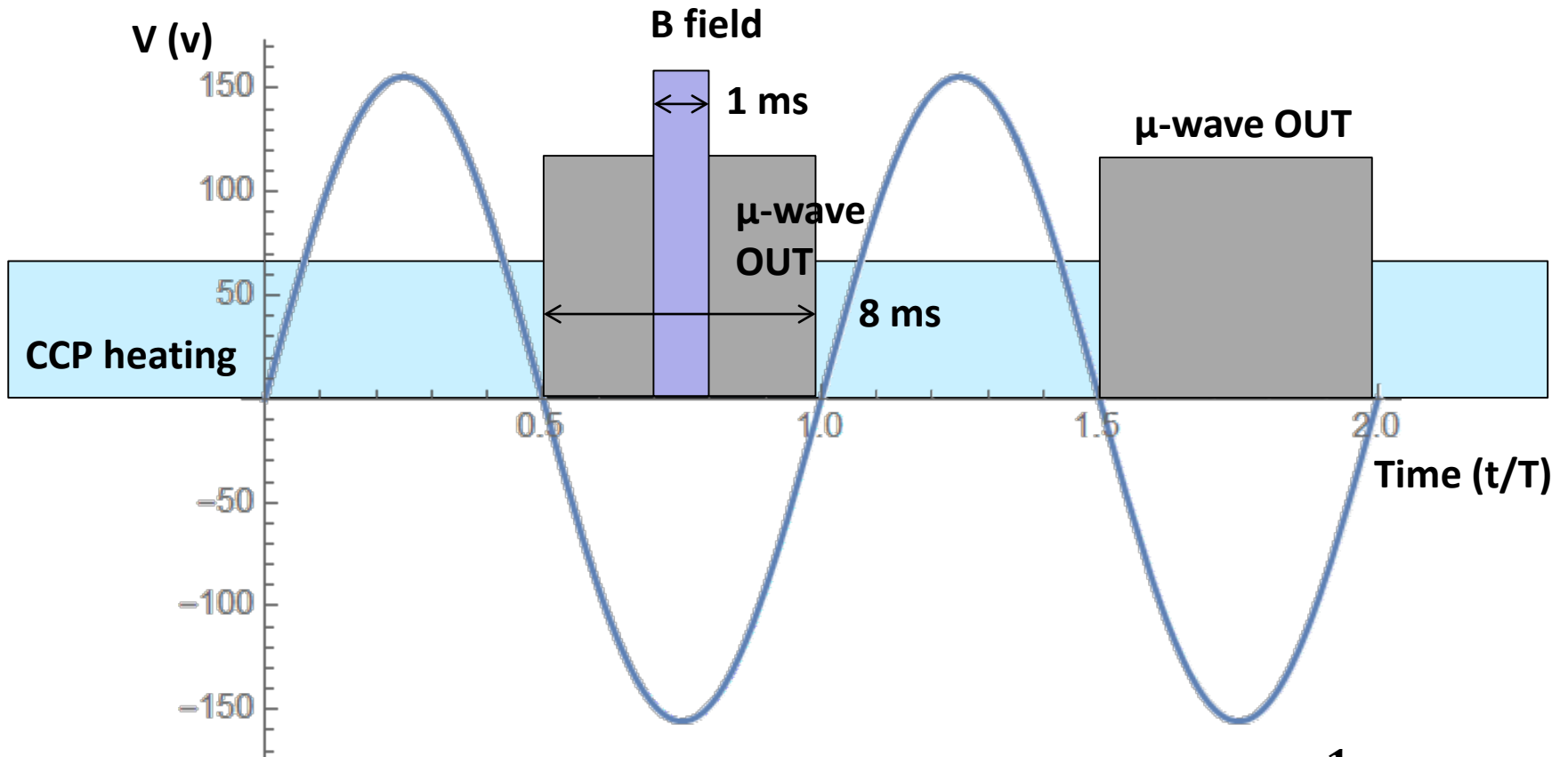
# The energy coupling efficiency is lower using the simple PFN



$$E = \frac{1}{2} CV^2 = 2.25 \text{kJ}$$

- Only 4.4 % of the energy is transferred to magnetic energy.

# Time sequence

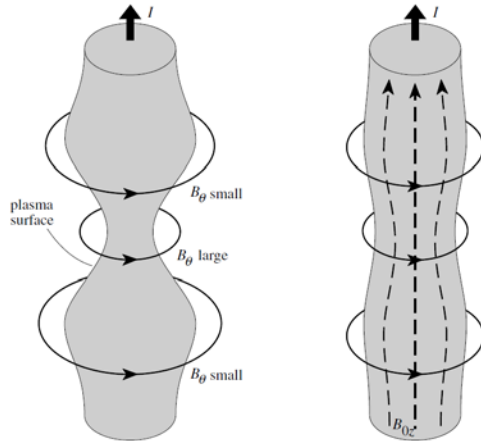


$$T = \frac{1}{60} = 16.7 \text{ ms}$$

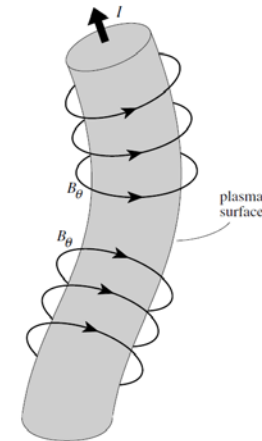
# Instabilities occur in a cylindrical plasma column



- Sausage instability:



- Kink instability:



- Safety factor  $q$ :

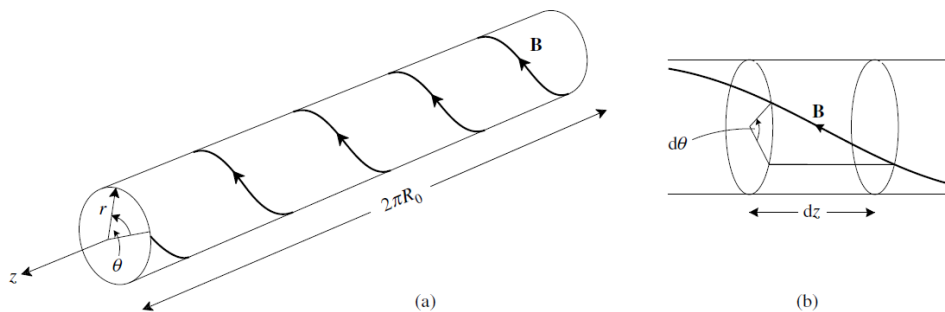
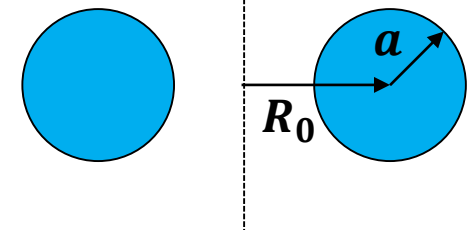


Fig. 4.6. Screw pinch geometry.

$$q(r) = \frac{rB_r(r)}{R_0B_\theta(r)} \approx \frac{rB_t}{R_0B_p} \quad (R_0 \gg a)$$



# A plasma current of ~ 2 kA is needed

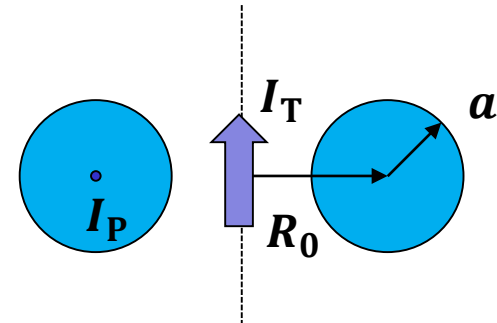


$$q(r) \approx \frac{rB_t}{R_0B_p} \approx \frac{aB_t}{R_0B_p}$$

$$B_T = \frac{\mu_0 I_T}{2\pi R_0} \quad B_P = \frac{\mu_0 I_p}{2\pi a}$$

$$I_p \sim \frac{1}{q} \left( \frac{a}{R_0} \right)^2 I_T = \frac{1}{3} \left( \frac{5}{10} \right)^2 20\text{kA} \sim 2\text{kA}$$

$$B_p \sim 40 \text{ G}$$



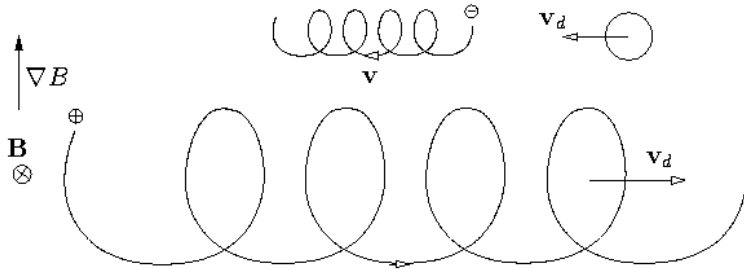
$R_0 \sim 10 \text{ cm}$   
 $a \sim 5 \text{ cm}$



# Plasma current will be generated by the Grad-B drift and the Curvature drift current

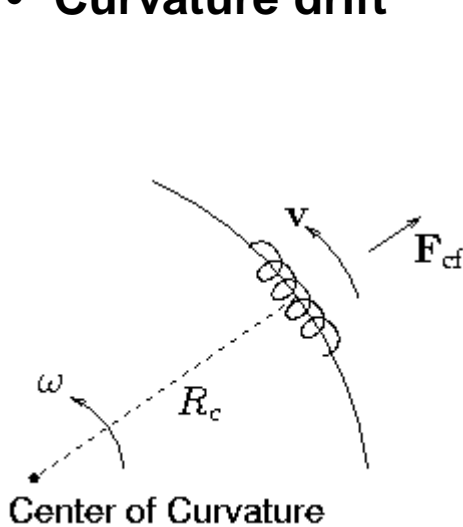


- **Grad-B drift**



$$V_{\nabla B} = \pm \frac{1}{2} v_{\perp} r_L \frac{\vec{B} \times \nabla B}{B^2}$$

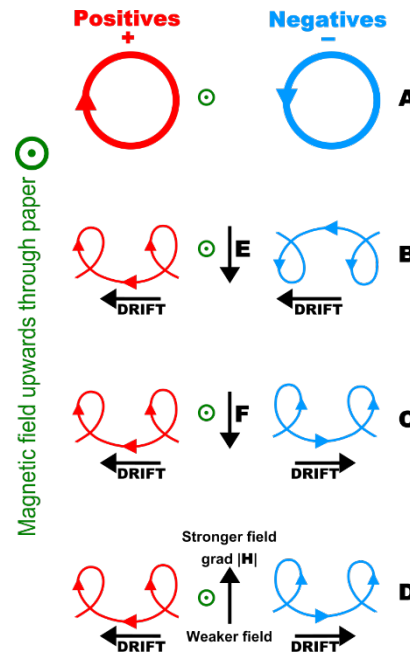
- **Curvature drift**



$$V_R = \frac{mv_{\parallel}^2}{q} \frac{\vec{R}_c \times \vec{B}}{R_c^2 B^2}$$

$$V_R + V_{\nabla B} = \frac{m}{q} \left( v_{\parallel}^2 + \frac{1}{2} v_{\perp}^2 \right) \frac{\vec{R}_c \times \vec{B}}{R_c^2 B^2}$$

$$\approx \frac{1}{q} (2T_{\parallel} + T_{\perp}) \frac{\vec{R}_c \times \vec{B}}{R_c^2 B^2}$$



# A vertical field $B_V$ of 12 G with a curvature of 5 cm is needed to generate the required plasma current



- For  $P = 10^{-1}$  Torr = 13 Pa = 13 N/m<sup>2</sup>

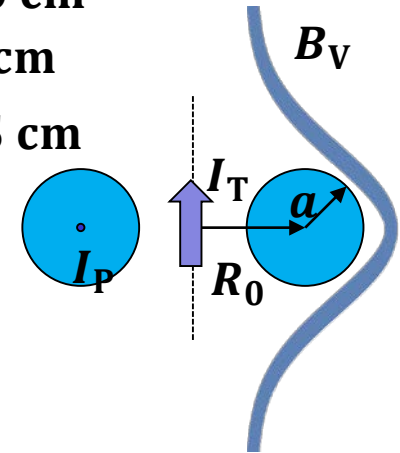
$$R_0 \sim 10 \text{ cm}$$

$$a \sim 5 \text{ cm}$$

$$R_C \sim 5 \text{ cm}$$

$$n = \frac{P}{T} = \frac{13}{4.1 \times 10^{-21}} = 3.1 \times 10^{21} \text{ m}^{-3}$$

Assuming the ionization fraction is 1%:



$$n_e = n_i = 3.1 \times 10^{19} \text{ m}^{-3}$$

$$j = qn_e v \quad I \sim \pi a^2 j = \pi a^2 q n_e v$$

$$v = \frac{I}{\pi a^2 q n_e} = \frac{2 \times 10^3}{\pi 0.05^2 \times 1.6 \times 10^{-19} \times 3.1 \times 10^{19}} \sim 5 \times 10^4 \text{ cm/s}$$

$$v_{\text{drift}} = V_R + V_{\nabla B} \approx \frac{1}{q} (2T_{\parallel} + T_{\perp}) \frac{\vec{R}_c \times \vec{B}_V}{R_c^2 B_V^2} \sim \frac{3T}{q} \frac{1}{R_c B_V}$$

$$B_V \sim \frac{1}{V_{\text{drift}}} \frac{3T}{q} \frac{1}{R_c} \sim \frac{1}{5 \times 10^4} 3 \times 1 \times \frac{1}{0.05} \sim 0.0012 \text{ T} = 12 \text{ G} \quad (B_{\text{earth}} \sim 0.5 \text{ G})$$

- For  $T_e = 1$  eV,  $B_V = 12$  G

$$r_c = \frac{\sqrt{2mT}}{eB_V} = \frac{\sqrt{2 \times 9.11 \times 10^{-31} \times 1.6 \times 10^{-19}}}{1.6 \times 10^{-19} \times 0.0012} = 2.8 \text{ mm}$$

# The prospective system design



- (1) Vertical field coil (VF coil):  $B_v=12$  G w/ curvature of 5 cm.
- (2) Pulse forming network for driving VF coil: ? kA.
- (3) Rogowski coil for measuring plasma current:  $I_p = 2$  kA.
- (4) Triple probe for measuring Plasma characteristics:  $T_e \sim 1$  eV,  $n_e \sim 10^{19}$  m<sup>-3</sup>.

